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(54) **NON-VOLATILE MEMORY DEVICE AND
INITIALIZATION INFORMATION READING
METHOD THEREOF**

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(57) **ABSTRACT**

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Related U.S. Application Data

In a method of reading initialization information from a non-volatile memory device, when power-up is detected, the non-volatile memory device divides a source voltage to generate a low read pass voltage which is to be provided to unselected word lines in an initialization information read operation. The low read pass voltage is set as at least one voltage between a ground voltage and the source voltage. The non-volatile memory device allows the source voltage not to be pumped in the initialization information read operation, based on the power-up. In the initialization information read operation, the non-volatile memory device provides the low read pass voltage to the unselected word lines and provides a read voltage to a selected word line to read initialization information stored in the memory cells.

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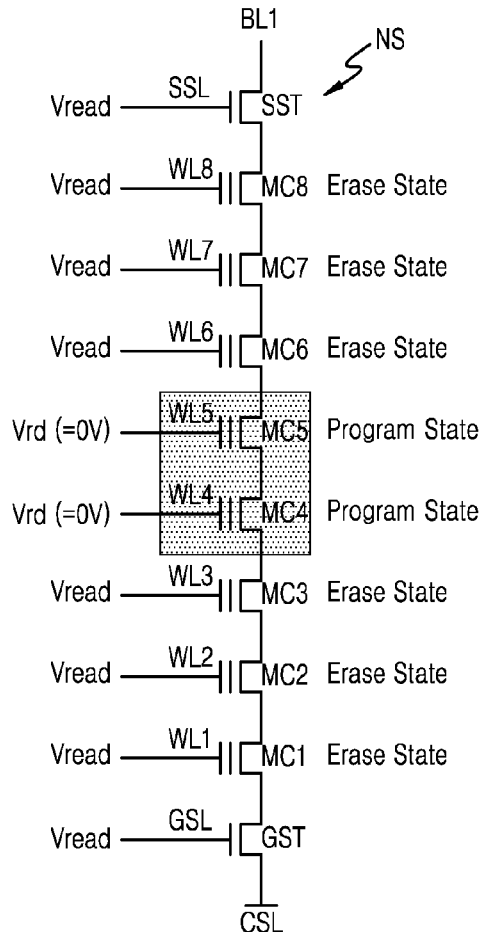


FIG. 1

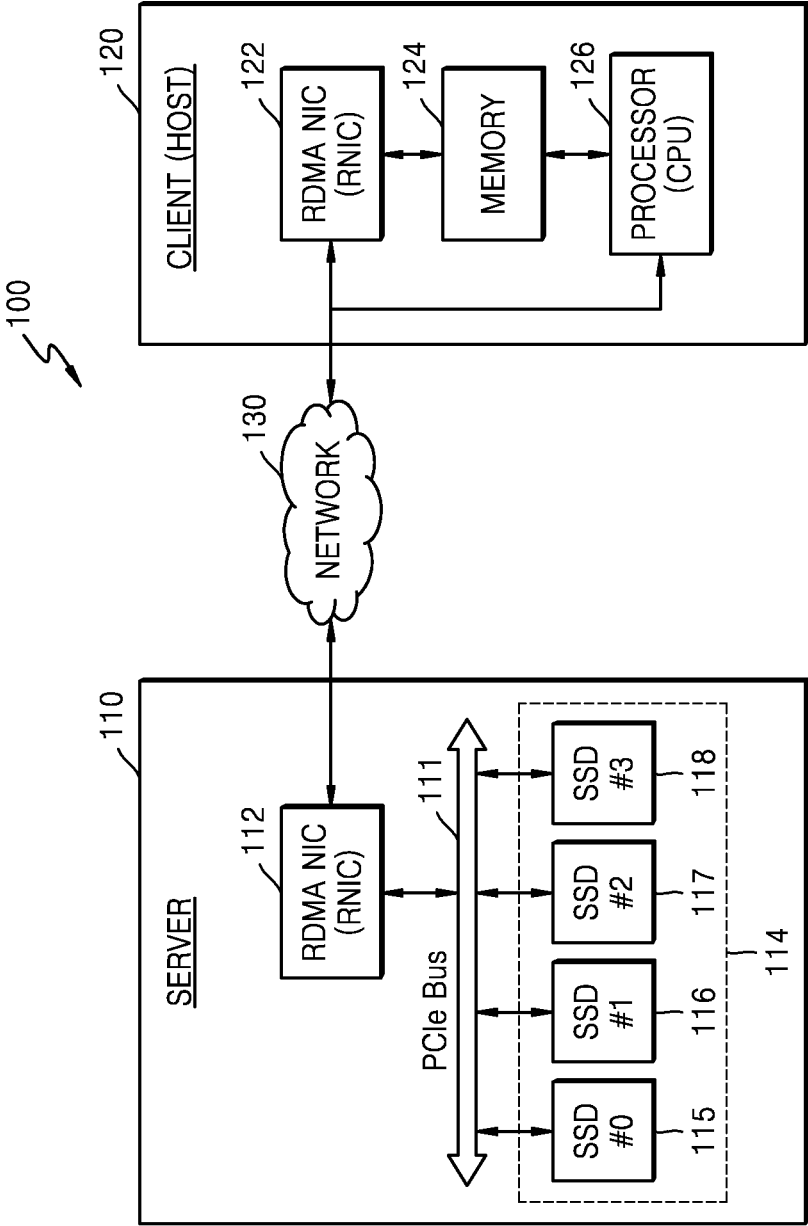


FIG. 2

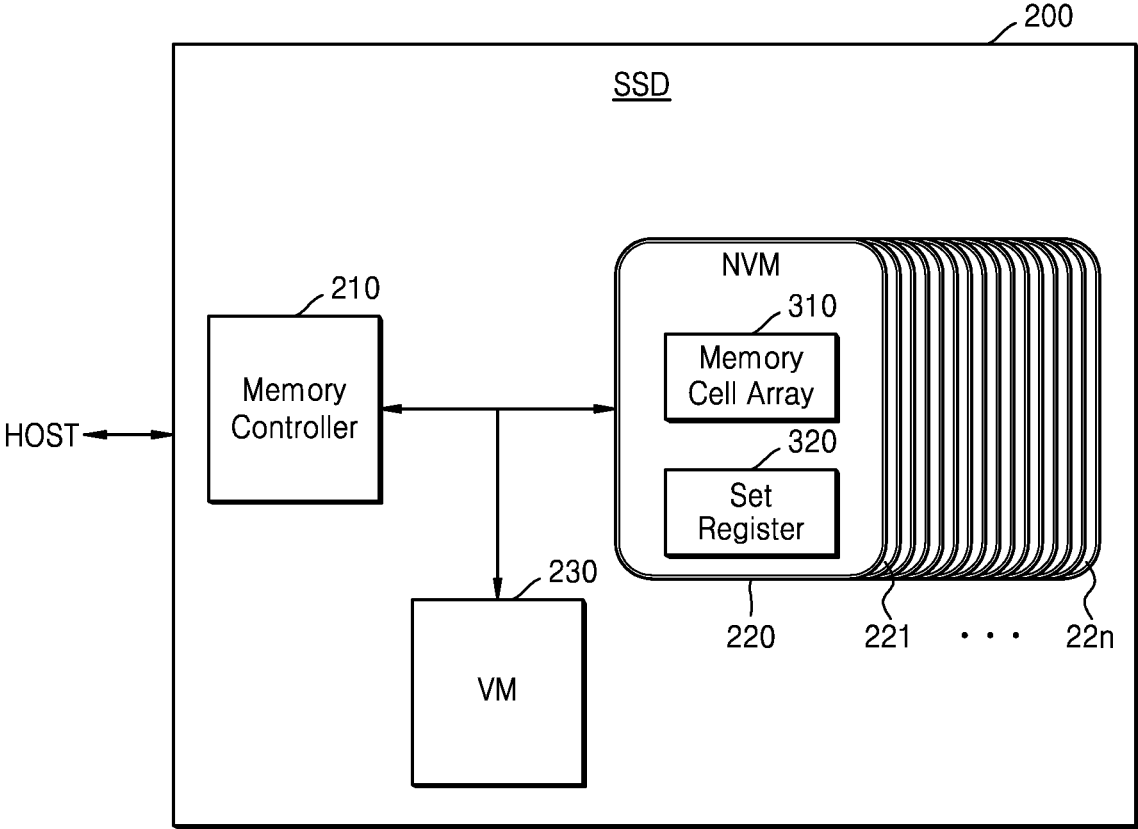


FIG. 3

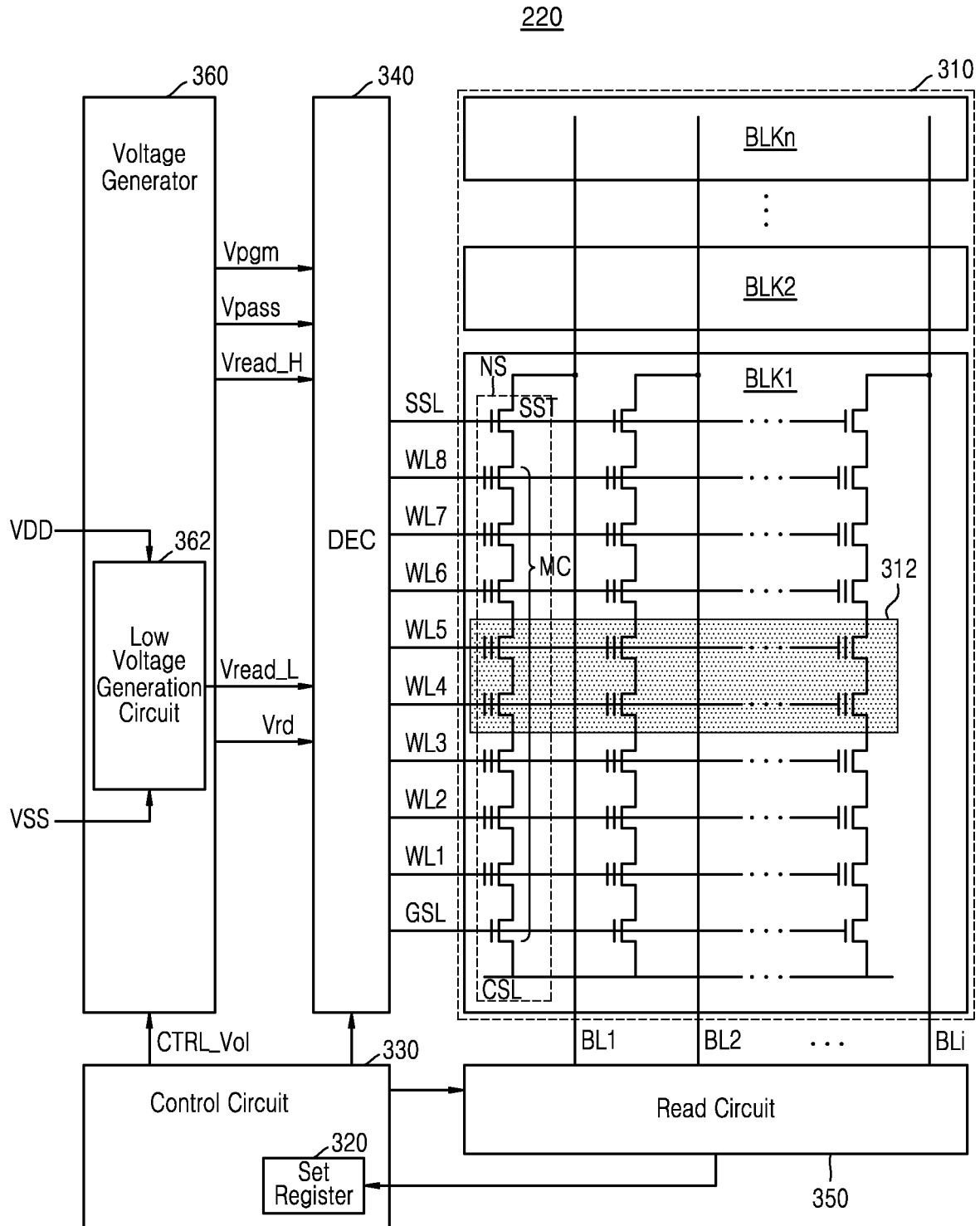


FIG. 4

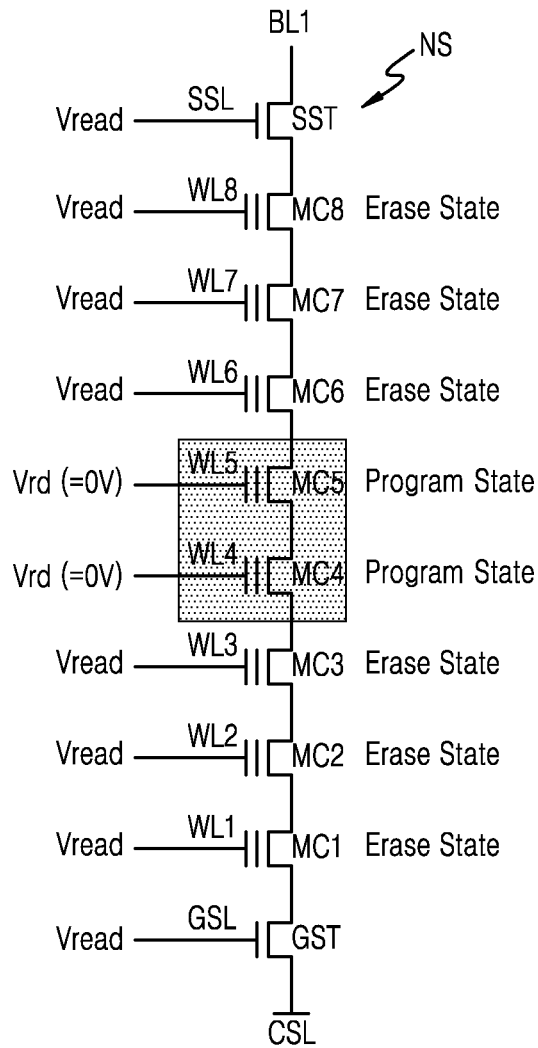


FIG. 5

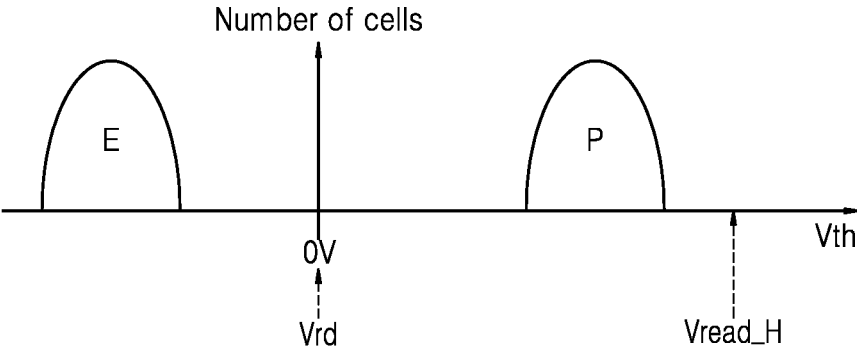


FIG. 6

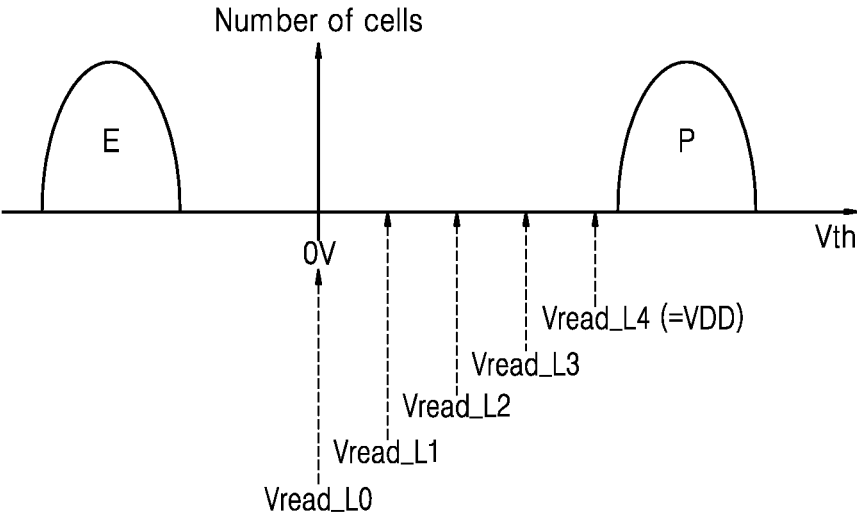


FIG. 7

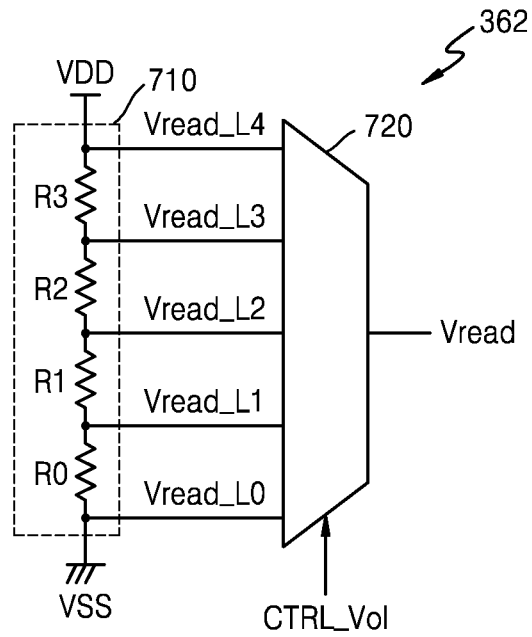


FIG. 8

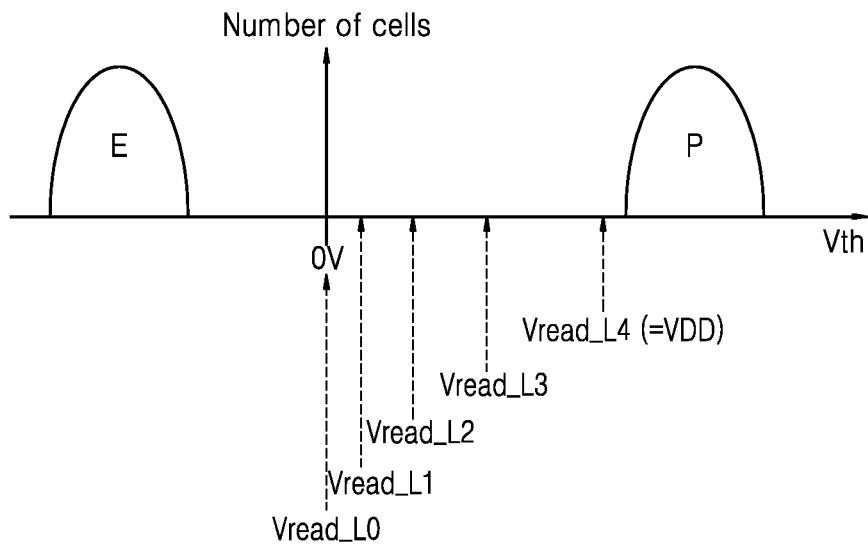


FIG. 9

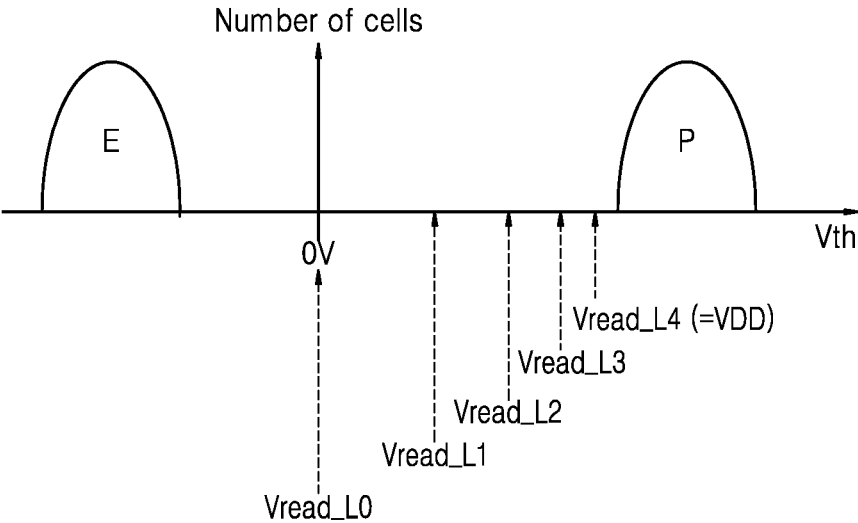


FIG. 10

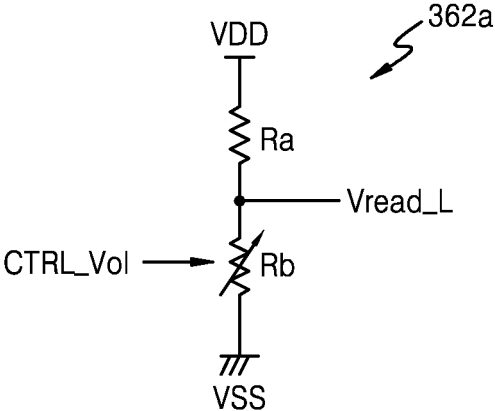


FIG. 11

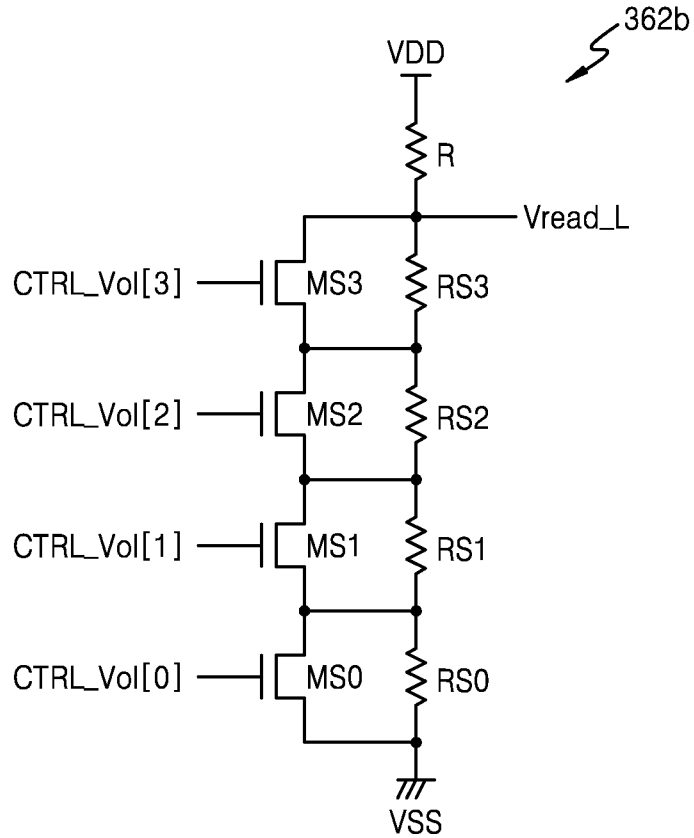


FIG. 12

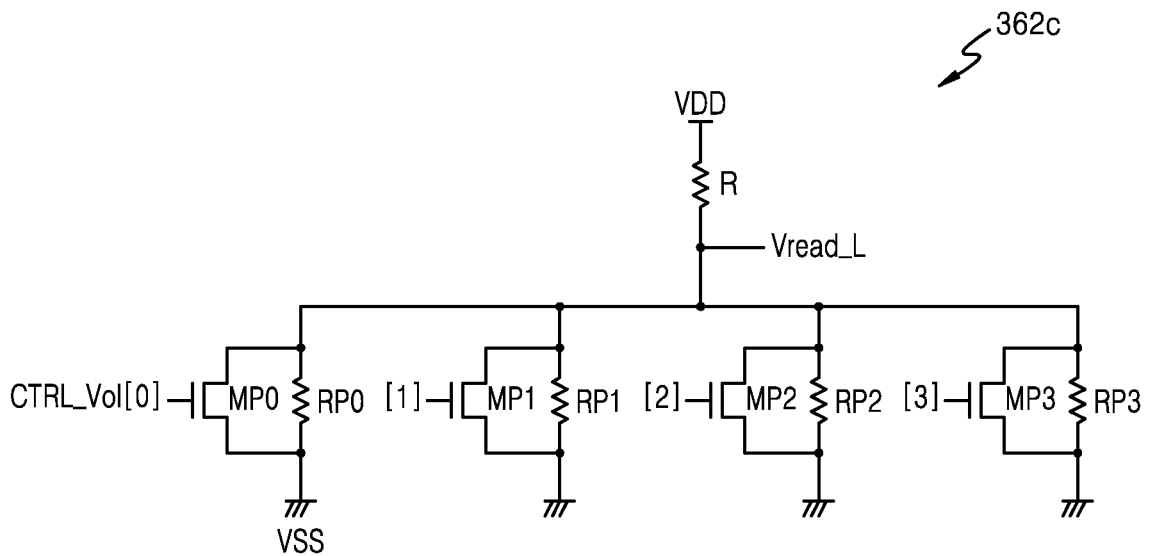


FIG. 13

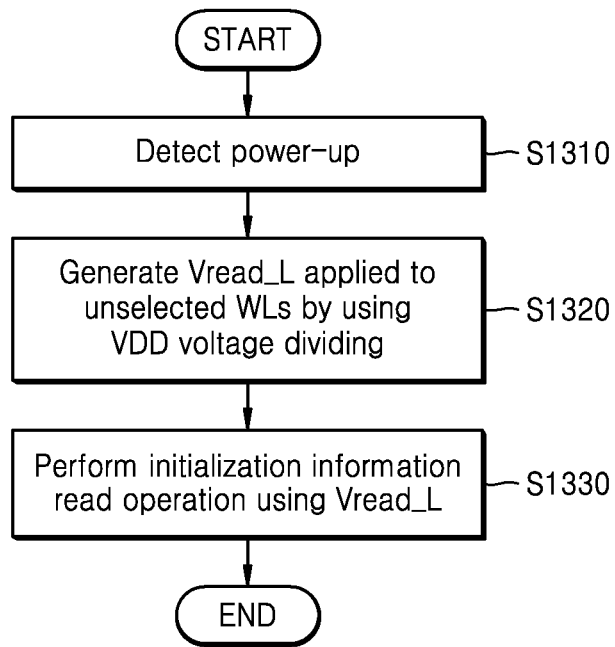


FIG. 14

Initialization Information Read Operation

	FIG. 5	FIG. 6
Unselected WLs	Vread_H	Vread_L
Selected WL	Vrd	Vrd

FIG. 15

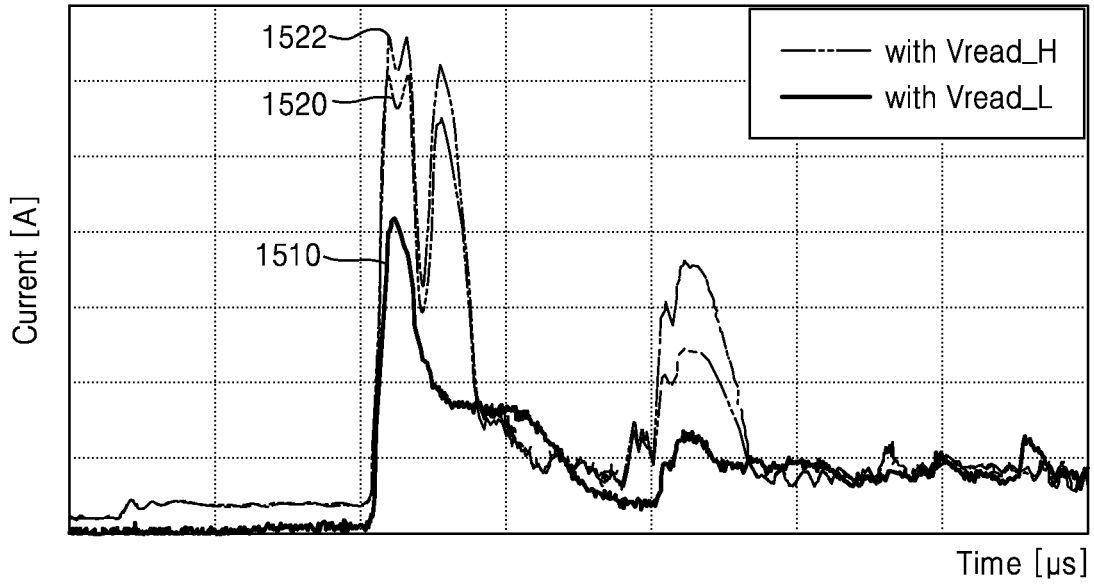


FIG. 16

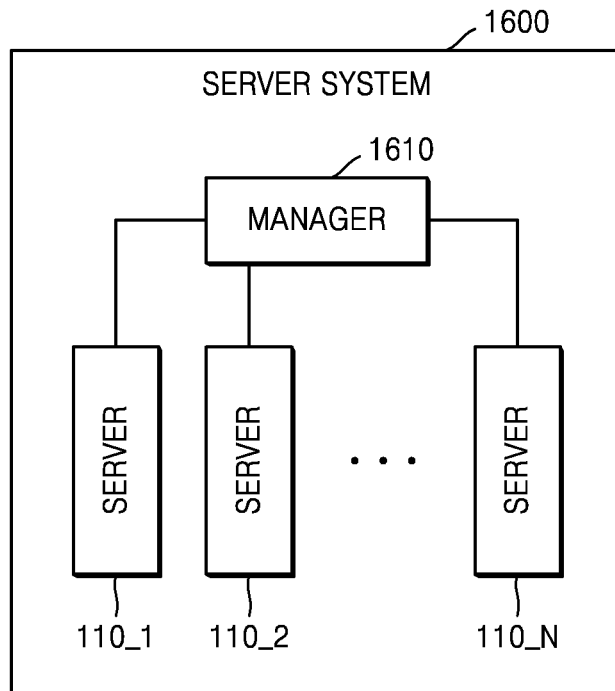


FIG. 17

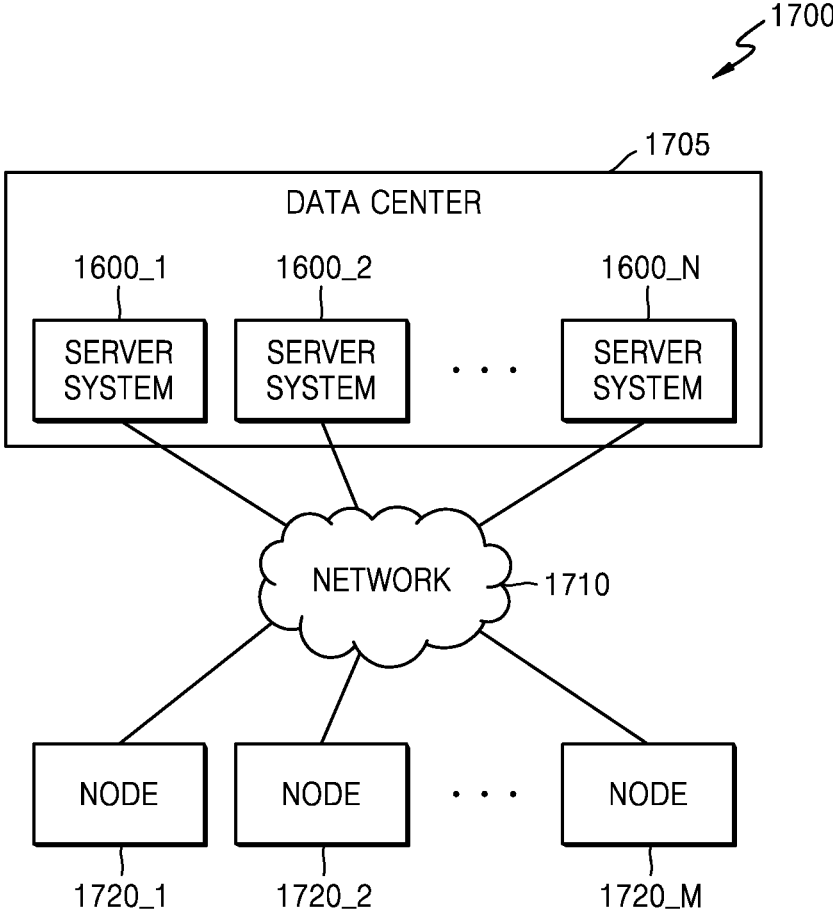


FIG. 18

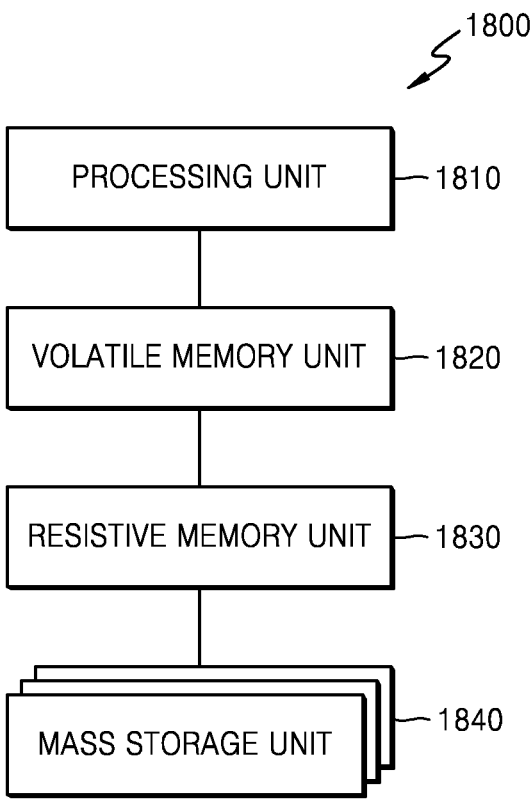


FIG. 19

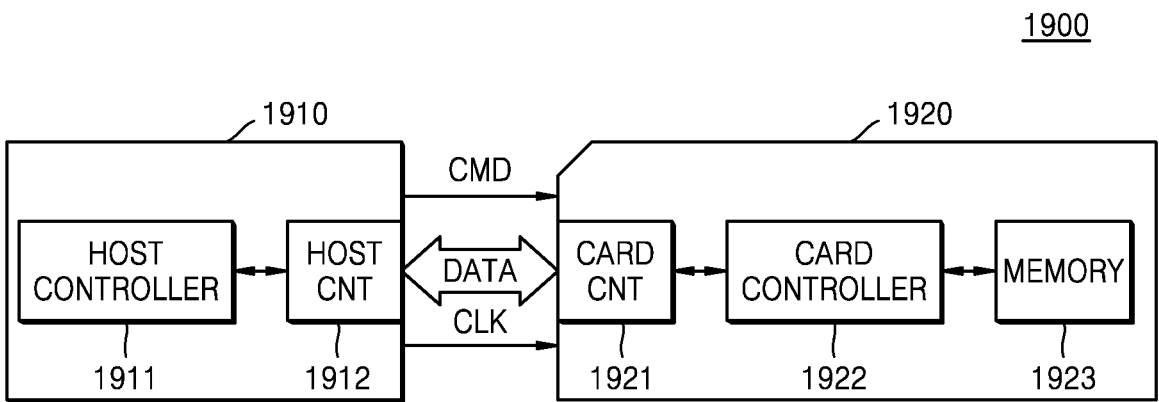
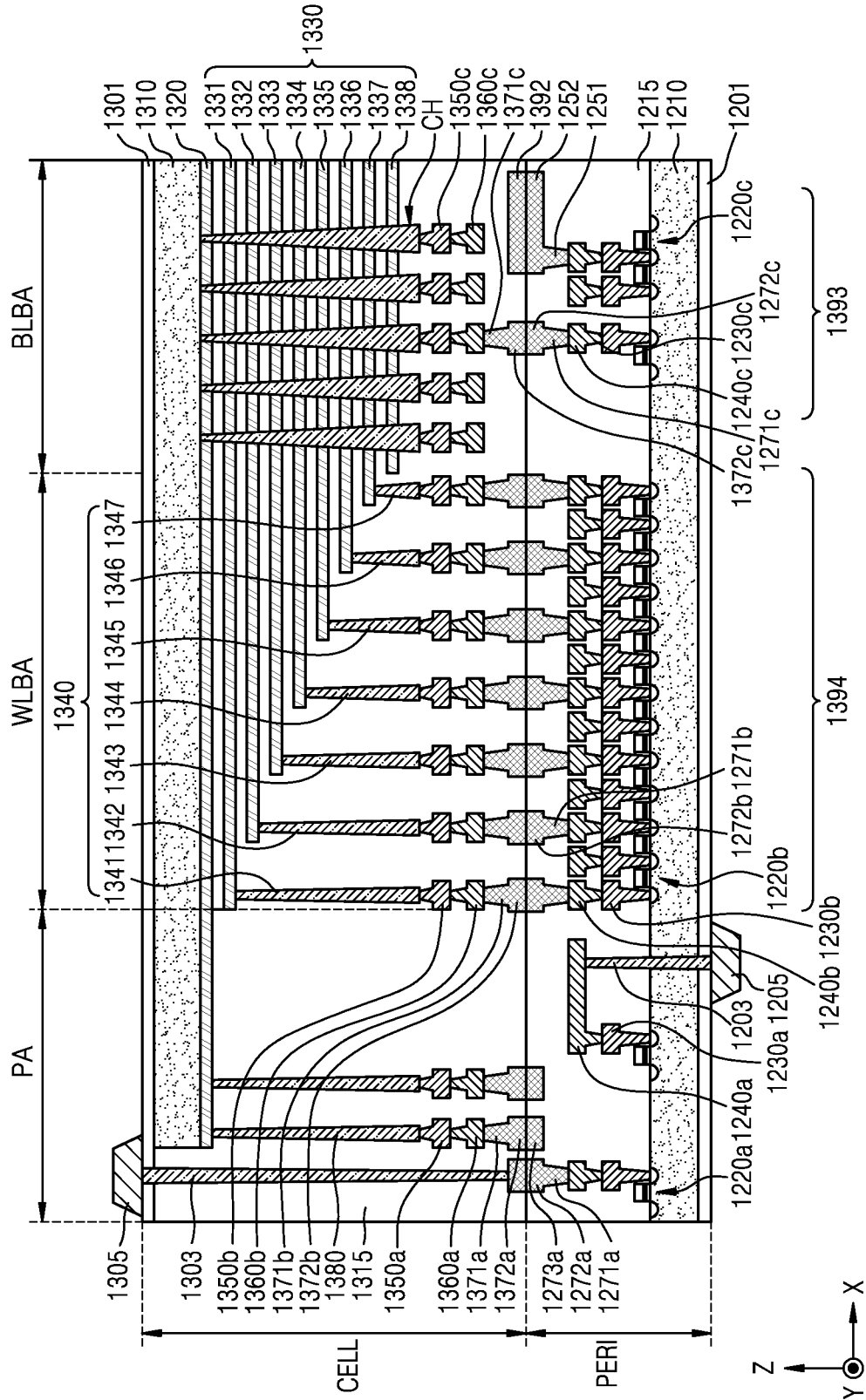


FIG. 20



**NON-VOLATILE MEMORY DEVICE AND
INITIALIZATION INFORMATION READING
METHOD THEREOF**

CROSS-REFERENCE TO RELATED
APPLICATION

[0001] This application is a continuation in part application of our copending application Ser. No. 16/181,176 filed Nov. 5, 2018, which claims the benefit of Korean Patent Application No. 10-2018-0042921, filed on Apr. 12, 2018, in the Korean Intellectual Property Office, the disclosure of which is incorporated herein in its entirety by reference.

BACKGROUND

[0002] The inventive concept relates to a non-volatile memory device, and more particularly, to a non-volatile memory device, a voltage generation method, a read method, and a memory system and an electronic device each including the non-volatile memory device, which may reduce a consumption current while an initialization information read operation for the non-volatile memory device is being performed.

[0003] Solid state drives (SSDs) are high-performance and high-speed storage devices which store data in non-volatile memory devices. Non-volatile memory express (NVMe), which is an ultrahigh-speed data transmission standard optimized for accessing SSDs, is being applied to SSDs. NVMe provides direct input/output (I/O) access to storage devices (or non-volatile memory devices) equipped in peripheral component interconnect express (PCIe) interfaces.

[0004] The amount of content applied to a storage system including a storage device and a host is increasing. Therefore, the requirements for mass storage devices are increasing continuously. NVMe SSDs are mass storage devices each including a plurality of non-volatile memory devices each in turn including flash memory cells. NVMe-over fabrics (NVMe-oF) is an NVMe SSD-based storage array and may expand to fabrics capable of performing communication in a large scale parallel manner.

[0005] In non-volatile memory devices, initialization information including product content may be stored in NAND flash memory cells and may be read in a booting operation of applying power to the device. When the number of non-volatile memory devices included in NVMe SSDs or NVMe-oF increases considerably, the number of non-volatile memory devices required to read initialization information increases, and due to this, a consumption current and a consumption current peak based on an initialization information read operation increase.

SUMMARY

[0006] The inventive concept provides a non-volatile memory device, a voltage generation method, a read method, and a memory system and an electronic device each including the non-volatile memory device, which may reduce a consumption current while an initialization information read operation is being performed.

[0007] According to an aspect of the inventive concept, there is provided a non-volatile memory device including: a memory cell array configured to store initialization information for the non-volatile memory device in memory cells connected to a plurality of word lines; a control circuit configured to control application of a first read voltage to a

selected word line and to control application of a second read voltage to unselected word lines in an initialization information read operation of reading the initialization information; and a voltage generator configured to decrease a source voltage to generate the second read voltage in response to a voltage control signal provided from the control circuit in the initialization information read operation.

[0008] According to another aspect of the inventive concept, there is provided a memory system including at least one non-volatile memory device and a memory controller configured to control the at least one non-volatile memory device, wherein the at least one non-volatile memory device includes: a memory cell array configured to store initialization information for the non-volatile memory device in memory cells connected to a plurality of word lines; a control circuit configured to control application of a first read voltage to a selected word line and to control application of a second read voltage to unselected word lines in an initialization information read operation of reading the initialization information; and a voltage generator configured to decrease a source voltage to generate the second read voltage in response to a voltage control signal provided from the control circuit in the initialization information read operation.

[0009] According to yet another aspect of the inventive concept, there is provided a read method of a non-volatile memory device, the read method including: detecting power-up; in response to the detected power-up, reading initialization information for the non-volatile memory device stored in memory cells of the non-volatile memory device; and when reading the initialization information, generating a first read voltage which is to be provided to a selected word line of a plurality of word lines connected to the memory cells, and generating a second read voltage which is to be provided to unselected word lines of the plurality of word lines connected to the memory cells, wherein the second read voltage is generated by decreasing a source voltage.

[0010] According to yet another aspect of the inventive concept, there is provided a method including: a non-volatile memory device detecting a power-up state for the memory device; and in response to detecting the power up state, the non-volatile memory device reading initialization information for the non-volatile memory device which is stored in first memory cells of a memory cell array of the non-volatile memory device and setting the initialization information for the non-volatile memory device in a set register of the non-volatile memory device. Reading the initialization information for the non-volatile memory device which is stored in first memory cells of a memory cell array of the non-volatile memory device comprises: applying to selected word lines connected to the first memory cells a first read voltage having a voltage level for discriminating between erase states and program states of the first memory cells; and while applying the first read voltage to the selected word lines, applying to unselected word lines which are not connected to the first memory cells a second read voltage which is less than voltage levels of the programs states of the first memory cells.

[0011] According to an exemplary embodiment of the inventive concept there is provided a memory module including: a memory cell region including a first metal pad; a peripheral circuit region including a second metal pad and

being vertically connected to the memory cell region by the first metal pad and the second metal pad; a memory cell array provided in the memory cell region, having memory cells connected to a plurality of word lines and being configured to store initialization information for the non-volatile memory device in the memory cells; a voltage generator provided in the peripheral circuit region and being configured to receive a source voltage, generate a first read voltage from the source voltage, and generate a second read voltage from the source voltage, wherein the magnitude of the second read voltage exceeds the magnitude of the first read voltage and is less than or equal to the magnitude of the source voltage; and a control circuit provided in the peripheral circuit region and being configured to control application of the first read voltage to a selected word line among the plurality of word lines, and control application of the second read voltage to unselected word lines among the plurality of word lines, in an initialization information read operation of reading the initialization information, wherein: the voltage generator is configured to generate the second read voltage based on a voltage control signal provided by the control circuit in the initialization information read operation, the voltage generator is configured to generate a third read voltage from the source voltage in a read operation of reading non-initialization information from first memory cells of the memory cell array, wherein the third read voltage is greater than the source voltage, and the control circuit is configured to apply the third read voltage to other unselected word lines, among the plurality of word lines, to read the non-initialization information from the first memory cells of the memory cell array.

[0012] According to an exemplary embodiment of the inventive concept there is provided a non-volatile memory device in a solid state drive (SSD) including: a memory cell region including a first metal pad; a peripheral circuit region including a second metal pad and being vertically connected to the memory cell region by the first metal pad and the second metal pad; a memory cell array provided in the memory cell region and configured to store initialization information for the non-volatile memory device in memory cells of the memory cell array, the memory cells being connected to a plurality of word lines; a voltage generator provided in the peripheral circuit region and configured to receive a source voltage, generate a first read voltage from the source voltage, and generate a second read voltage from the source voltage, wherein the second read voltage is greater than the first read voltage and is less than or equal to the source voltage; and a control circuit provided in the peripheral circuit region and configured to detect power-up of the non-volatile memory device, generate a voltage control signal based on detecting a power-up state of the non-volatile memory, perform an initialization information read operation of reading the initialization information, the initialization information read operation applying the first read voltage to a selected word line among the plurality of word lines and applying the second read voltage to unselected word lines among the plurality of word lines, perform a read operation of reading non-initialization information, and output initialization information through an input/output pad in the peripheral circuit region to a memory controller in the SSD, wherein: the voltage generator is configured to generate the second read voltage based on the voltage control signal provided by the control circuit in the initialization information read operation, the voltage generator is

configured to generate a third read voltage from the source voltage in the read operation, wherein the third read voltage is greater than the source voltage, and the control circuit is configured to apply the first read voltage to another selected word line, among the plurality of word lines, and apply the third read voltage to other unselected word lines, among the plurality of word lines, to read the non-initialization information from other memory cells of the memory cell array.

[0013] According to an exemplary embodiment of the inventive concept there is provided a method including: controlling, by a memory controller, an initialization information read operation and a read operation of a non-volatile memory device, the initialization information read operation reading initialization information for the non-volatile memory device, which is stored in first memory cells of a memory cell array of the non-volatile memory device, and the read operation reading non-initialization information for the non-volatile memory device, which is stored in a second memory cells of the memory cell array; detecting, by the non-volatile memory device, a power-up state of the non-volatile memory device; based on detecting of the power-up state, performing, by the non-volatile memory device, the initialization information read operation; and outputting, by the non-volatile memory device, the initialization information read in the initialization information read operation to the memory controller, wherein: the initialization information read operation comprises: applying to selected word lines connected to the first memory cells a first read voltage having a first read voltage level for discriminating between erase states and program states of the first memory cells; and while applying the first read voltage to the selected word lines, applying to unselected word lines which are not connected to the first memory cells a second read voltage having a second read voltage level which is less than voltage levels of the program states of the first memory cells, the magnitude of the second read voltage exceeds the magnitude of the first read voltage and is less than or equal to the magnitude of a source voltage used to generate each of the first read voltage and the second read voltage, and the read operation comprises: applying the first read voltage to another selected word line, among the word lines; and applying a third read voltage whose magnitude exceeds that of the source voltage to other unselected word lines, among the word lines, to thereby read the non-initialization information from other memory cells of the non-volatile memory device.

BRIEF DESCRIPTION OF THE DRAWINGS

[0014] Embodiments of the inventive concept will be more clearly understood from the following detailed description taken in conjunction with the accompanying drawings.

[0015] FIG. 1 illustrates a conceptual embodiment of a data processing system as an electronic device to which an embodiment of a non-volatile memory device is applied.

[0016] FIG. 2 is a block diagram illustrating a schematic configuration of a solid state driver (SSD) which is a memory system including an embodiment of a non-volatile memory device.

[0017] FIG. 3 is a block diagram for describing an embodiment of the non-volatile memory device illustrated in FIG. 2.

[0018] FIGS. 4 and 5 are diagrams for describing a first memory block of FIG. 3.

[0019] FIG. 6 is a diagram for conceptually describing an embodiment of an initialization information reading.

[0020] FIGS. 7, 8 and 9 are diagrams for describing an exemplary embodiment of the low voltage generation circuit of FIG. 3.

[0021] FIGS. 10, 11 and 12 are diagrams for describing other exemplary embodiments of the low voltage generation circuit of FIG. 3.

[0022] FIG. 13 is a flowchart illustrating an embodiment of an initialization information reading method of the non-volatile memory device illustrated in FIG. 3.

[0023] FIG. 14 is a table showing an example where word line voltages are applied based on an initialization information read operation of FIG. 13.

[0024] FIG. 15 is a diagram illustrating a consumption current pattern when an initialization information read operation is performed by using the embodiment of a non-volatile memory device illustrated in FIG. 3.

[0025] FIG. 16 is a block diagram illustrating a server system to which a storage device including embodiments of a non-volatile memory device is applied.

[0026] FIG. 17 is a block diagram illustrating a storage cluster to which a storage device including embodiments of a non-volatile memory device are applied.

[0027] FIG. 18 is a block diagram illustrating a system including embodiments of a non-volatile memory device.

[0028] FIG. 19 is a block diagram illustrating an example where embodiments of a non-volatile memory device are applied to a memory card system.

[0029] FIG. 20 illustrates a portion of a cross-section of the non-volatile memory device of FIG. 3.

DETAILED DESCRIPTION OF THE EMBODIMENTS

[0030] FIG. 1 illustrates a conceptual embodiment of a data processing system 100 as an electronic device to which an embodiment of a non-volatile memory device is applied.

[0031] Referring to FIG. 1, data processing system 100 may include a plurality of peers 110 and 120, which communicate with each other by using a remote direct memory access (RDMA) protocol. Peers 110 and 120 may each be a storage system or a computer system, which transmits or receives data over a network 130. Peers 110 and 120 may be provided as, and remote direct memory access (RDMA) connections may be provided between, for example, clients, servers, server farms, server clusters, application servers, or message servers.

[0032] Peers 110 and 120 are illustrated as a server 110 and a client 120. Server 110 may denote a peer which receives a request of client 120 over network 130, performs a service, and transmits a result of the service to client 120. Client 120 may denote a peer which issues a request to server 110 and waits for a response. Client 120 may be referred to as a host.

[0033] RDMA may perform data transmission from one memory to another device or a memory of a system. The data transmission may be to perform direct memory access (DMA) over network 130 without a central processing unit (CPU) (or a processor) or an operating system (OS), and enables a high throughput, low latency, and low overhead data transmission.

[0034] Network 130 is illustrated as an individual single network, but may be an arbitrary type of network as understood by one of ordinary skill in the art. Network 130 may

be for personal use or common use, may be a wired network or a wireless network, or may be a whole network or a partial network. According to embodiments, network 130 may be a global network such as Internet or World Wide Web (referred to as Web), a wide area network (WAN), or a local area network (LAN).

[0035] Server 110 may include an RDMA network integrated circuit (RNIC) and a storage device 114, which are connected to a peripheral component interconnect express (PCIe) bus 111. PCIe is a high speed series computer extension bus standard which is designed for replacing PCI, PCI-X, and accelerated graphics port (AGP) bus standards. As compared to these other standards, PCIe may include improved performance-scaling and more detailed error detection and report mechanism for a higher maximum system bus throughput, a lower input/output (I/O) pin count, and a smaller physical throughput and bus devices.

[0036] RNIC 112 may be a network interface controller which supports a network interface card, a network adaptor, and/or RDMA. Storage device 114 connected to RNIC 112 may be implemented with a non-volatile memory express (NVMe) storage protocol using RDMA. The NVMe storage protocol may include, for example, one of an Internet wide area RDMA protocol (iWARP), an infiniband, and RDMA over converged Ethernet (RoCE).

[0037] Storage device 114 may include a plurality of storage elements 115 to 118, and storage elements 115 to 118 may be configured with NVMe solid state drives (NVMe SSDs) or PCIe SSDs. Storage device 114 may be implemented with NVMe-over fabrics (NVMe-oF). NVMe may be a scalable host controller interface which is designed to process the needs of a company, a data center, and a client system capable of using SSDs. NVMe may be used as an SSD device interface for proposing a storage entity interface to a host. NVMe may define a register interface optimized for NVMe SSDs, a command set, and a feature set, may use a functionality of NVMe SSDs, and may be located at a position for standardizing an NVMe SSD interface.

[0038] Client 120 may include an RNIC 122, a memory 124, and a processor (or a CPU) 126. Memory 124 may include a system memory, a main memory, a volatile memory, and a non-volatile memory. Memory 124 may be a volatile computer storage medium, a non-volatile computer storage medium, an attachable/detachable computer storage medium, or a non-detachable computer storage medium, which is implemented based on an arbitrary method or technology for storing a computer-readable command, a data structure, a program module, or other data. A computer storage medium may include random access memory (RAM), read-only memory (ROM), electrical erasable programmable read only memory (EEPROM), flash memory, or other memory technology, compact disk ROM (CD-ROM), digital versatile disk (DVD), or another optical storage, a magnetic cassette, a magnetic tape, a magnetic disk storage, or another magnetic storage, or another arbitrary medium, which is used to store desired information and is accessible by a computer system, but is not limited thereto.

[0039] Processor 126 may control an overall operation of data processing system 100. Processor 126 may include a plurality of processing cores, and the plurality of processing cores may each include a plurality of processing entries. Processor 126 may command a write or read operation of writing data in or reading from storage device 114 of server

110, based on a processing entry. For example, processor **126** may transmit a command to server **110** over network **130**, where the command causes the server **110** to start data transmission, for example transmission of data stored in storage device **114**.

[0040] RNIC **122** may be a network interface controller which supports a network interface card similar to RNIC **112** of server **110**, a network adaptor, and/or RDMA. RNICs **112** and **122** may support an RDMA protocol. RNICs **112** and **122** may support the RDMA protocol which allows direct transmission of data from storage device **114** to memory **124** and/or from memory **124** to storage device **114**. The data transmission may not need or include supervision by processor **126**. Therefore, the RDMA protocol may have good characteristics such as high bandwidth, low latency, and low overhead.

[0041] In data processing system **100**, storage elements (i.e., SSDs) **115** to **118** of server **110** may perform an initialization operation when power-up is detected in booting. An initialization operation of each of SSDs **115** to **118** may include an operation of reading initialization information stored in one or more non-volatile memory devices embedded into a corresponding SSD and setting the initialization information in a set register of the non-volatile memory device.

[0042] As SSDs increase in capacity, the number of non-volatile memory devices increases considerably, and thus, if non-volatile memory devices simultaneously perform an initialization information read operation, a consumption current of server **110** increases. Therefore, it is desired to develop a method of decreasing a consumption current based on an initialization information read operation of each of the non-volatile memory devices in an initialization operation of a mass SSD.

[0043] FIG. 2 is a block diagram illustrating a schematic configuration of an SSD **200** which is a memory system including an embodiment of a non-volatile memory device. SSD **200** of FIG. 2 may correspond to each of storage elements **115** to **118** of FIG. 1.

[0044] Referring to FIG. 2, SSD **200** may include a memory controller **210**, a plurality of non-volatile memory devices **220** to **22n**, and a volatile memory device **230**. Memory controller **210** may control read operations, program operations, erase operations, and/or initialization information read operations of the plurality of non-volatile memory devices **220** to **22n**, which may be in response to a request from a host connected to SSD **200**. The host may correspond to client **120** of FIG. 1.

[0045] According to embodiments, the host may be an arbitrary computing system such as a personal computer (PC), a server computer, a workstation, a laptop computer, a mobile phone, a smartphone, a personal digital assistant (PDA), a portable multimedia player (PMP), a digital camera, a digital television (TV), a set-top box, a music player, a portable game console, a navigation system, or the like.

[0046] The plurality of non-volatile memory devices **220** to **22n** may each be used as a storage medium of SSD **200**. Each of the plurality of non-volatile memory devices **220** to **22n** may be, for example, a NAND flash memory device. The plurality of non-volatile memory devices **220** to **22n** may be connected to memory controller **210** through a channel. In response to a request provided from the host through the channel, each of the plurality of non-volatile memory devices **220** to **22n** may perform a read operation,

a program operation, and the erase operation, and in booting, may perform an initialization information read operation.

[0047] Volatile memory device **230** may temporarily store write data provided from the host or data read from each of the plurality of non-volatile memory devices **220** to **22n**. Volatile memory device **230** may store metadata or cache data which is to be stored in the plurality of non-volatile memory devices **220** to **22n**. Volatile memory device **230** may include dynamic RAM (DRAM), static random access memory (SRAM), and/or the like.

[0048] The plurality of non-volatile memory devices **220** to **22n** may each include a memory cell array **310** and a set register **320**. Initialization information, which represents product content of a corresponding non-volatile memory device and is read through an initialization information read operation in booting, may be set in set register **320**. Also, set register **320** may be store data and control signals, received from memory controller **210**, for operation options, functions, characteristics, and operation modes of a corresponding non-volatile memory device.

[0049] Each of the plurality of non-volatile memory devices **220** to **22n** may store, as initialization information, protection information about the inhibition or permission of program/erase operations, trimming data for trimming an operating voltage level in an operation mode, column repair information for repairing a failed bit line, and bad block information including bad memory cells in a portion (see element **312** of FIG. 3) of memory cell array **310**. The trimming data may be data for voltage control in operation modes (i.e., a read operation, a program operation, and an erase operation) of each of the plurality of non-volatile memory devices **220** to **22n**, and moreover, may be data for controlling a sensing amplifier or a page buffer or setting initialization of a reference cell.

[0050] When power-up is detected in booting, SSD **200** may perform the initialization information read operation of each of the plurality of non-volatile memory devices **220** to **22n**. In SSD **220** having a large capacity, when the number of non-volatile memory devices **220** to **22n** increases considerably, the plurality of non-volatile memory devices **220** to **22n** may simultaneously perform the initialization information read operation, and due to this, a consumption current peak occurs and the amount of consumption current may exceed an allowable value or limit. At least one reason for this is because a read pass voltage needed for the initialization information read operation is generated through a pumping operation simultaneously performed by non-volatile memory devices **220** to **22n**. However, when the read pass voltage needed for the initialization information read operation is generated without the pumping operation in non-volatile memory devices **220** to **22n**, the consumption current peak and the amount of consumption current may be reduced.

[0051] Hereinafter, an example configuration of non-volatile memory device **220** of non-volatile memory devices **220** to **22n** of FIG. 2 will be described in detail.

[0052] FIG. 3 is a block diagram for describing an example embodiment of non-volatile memory device **220** illustrated in FIG. 2.

[0053] Referring to FIG. 3, non-volatile memory device **220** may include a memory cell array **310**, a control circuit **330**, an address decoder **340**, a read circuit **350**, and a voltage generator **360**. Although not shown, non-volatile memory device **220** may further include a write circuit and

an I/O circuit. The write circuit may be configured with a write driver which receives data provided from memory controller **210** (see FIG. 2) to the I/O circuit through an I/O line and stores the received data in memory cell array **310**. The I/O circuit may temporarily store a command, an address, a control signal, and data provided through the I/O line from memory controller **210**. The I/O circuit may temporarily store read data of non-volatile memory device **220** and may output the read data to memory controller **210** through the I/O line at a predetermined time.

[0054] Memory cell array **310** may include a plurality of memory cells, and for example, the plurality of memory cells may be flash memory cells. Hereinafter, an example where the plurality of memory cells are NAND flash memory cells will be described as an example of embodiments. Memory cell array **310** may include a three-dimensional (3D) memory cell array including a plurality of NAND strings.

[0055] The 3D memory cell array may be a circuit that includes an active area disposed on a silicon substrate and is associated with an operation of each memory cell, and may be configured in a monolithic type on a physical level of at least one of memory cell arrays each including a circuit which is provided on or in the substrate. The monolithic type may denote that layers of levels configuring an array are stacked just on layers of lower levels of the array. In an embodiment, the 3D memory cell array may include a plurality of NAND strings which are arranged in a vertical direction in order for at least one memory cell to be disposed on another memory cell. The at least one memory cell may include a charge trap layer. U.S. Pat. Nos. 7,679,133, 8,553,466, 8,654,587 and 8,559,235 and U.S. Patent Application Publication No. 2011/0233648 disclose appropriate elements of a 3D memory array which includes a plurality of levels and in which word lines and/or bit lines are shared between the plurality of levels. These documents are incorporated herein by reference.

[0056] Memory cell array **310** may include a plurality of memory blocks (for example, first to nth memory blocks) BLK1 to BLKn. The plurality of memory blocks BLK1 to BLKn may be connected to string selection lines SSLs, word lines WLs, ground selection lines GSLs, and bit lines BLs. The plurality of memory blocks BLK1 to BLKn may be connected to address decoder **340** through the string selection lines SSLs, the word lines WLs, and the ground selection lines GSLs and may be connected to read circuit **350** through the bit lines BLs.

[0057] The first memory block BLK1 may include a plurality of NAND strings NSs, and the plurality of NAND strings NSs may each include a string selection transistor SST, a plurality of memory cells MCs, and a ground selection transistor GST, which are connected in series. The string selection transistor SST may be connected to a string selection line SSL, each of the plurality of memory cells MCs may be connected to corresponding word lines WL1 to WL8, and the ground selection transistor GST may be connected to a ground selection line GSL. The string selection transistor SST may be connected to corresponding bit lines BL1 to BLi, and the ground selection transistor GST may be connected to a common source line GSL.

[0058] The number of columns and rows of the NAND strings NSs of the first memory block BLK1 may increase or decrease. As the number of columns of the NAND strings NSs varies, the number of word lines WLs may vary. As the

number of rows of the NAND strings NSs varies, the number of bit lines BLs connected to the columns of the NAND strings NSs and the number of NAND strings NSs connected to one string selection line SSL may vary. A height of each of the NAND strings NSs may increase or decrease. For example, the number of memory cells stacked in each of the NAND strings NSs may increase or decrease. **[0059]** One-bit data may be stored in the memory cells of the first memory block BLK1. A memory cell for storing one-bit data in one memory cell may be referred to as a single level cell or a single bit cell.

[0060] The first memory block BLK1 may be set as a block which stores initialization information about non-volatile memory device **220**. For example, it may be assumed that the initialization information about non-volatile memory device **220** is stored in a whole portion or a portion **312** of the first memory block BLK1. The memory cells in which the initialization information is stored may be referred to as "first memory cells" and the word lines which are connected to these first memory cells may be referred to as selected word lines, while the other word lines which are not connected to the first memory cells may be referred to as unselected word lines.

[0061] The second to nth memory blocks BLK2 to BLKn, like the first memory block BLK1, may each include a plurality of memory cells and a plurality of selection transistors. Each of the second to nth memory blocks BLK2 to BLKn may be set as a block which stores data transferred from memory controller **210**. The memory cells of each of the second to nth memory blocks BLK2 to BLKn may be configured as multi-level cells (or multi-bit cells) for storing two or more-bit data in single level cells or one memory cell.

[0062] Control circuit **330** may control an overall operation of non-volatile memory device **220**. Control circuit **330** may control a read operation, a program operation, and/or an erase operation on memory cell array **310**, based on a command, an address, and control signals received from memory controller **210**.

[0063] Control circuit **330** may provide a row address to address decoder **340**, provide a column address to read circuit **350**, and provide a voltage control signal CTRL_Vol to voltage generator **360**. Control circuit **330** may detect power-up to generate the voltage control signal CTRL_Vol.

[0064] Control circuit **330** may control an operation of reading the initialization information stored in the first memory block BLK1 of memory cell array **310**. Control circuit **330** may control a read pass voltage Vread level needed for performing an initialization information read operation. Control circuit **330** may perform control in order for the read pass voltage Vread level to be less than or equal to a source voltage VDD level in the initialization information read operation, based on the voltage control signal CTRL_Vol provided from voltage generator **360**.

[0065] Control circuit **330** may include set register **320** which stores initialization information read through the initialization information read operation. It would be apparent to one of ordinary skill in the art that set register **320** may not be embedded into control circuit **330** in other embodiments.

[0066] Address decoder **340** may select one memory block from among the plurality of memory blocks BLK1 to BLKn of memory cell array **310** and may apply a word line voltage to each word line WL of the selected memory block. In a program operation, a program voltage Vpgm may be applied

to the selected word line, and a pass voltage V_{pass} may be applied to an unselected word line. In a read operation, a read voltage V_{rd} may be provided to the selected word line, and a high read pass voltage V_{read_H} having a high voltage level which is greater than the source voltage V_{DD} level may be provided to the unselected word line. In the initialization information read operation, the read voltage V_{rd} may be provided to the selected word line, and a low read pass voltage V_{read_L} generated by dividing the source voltage V_{DD} may be provided to the unselected word line. In the present specification, the read voltage V_{rd} may be referred to as a first read voltage, and the read pass voltage V_{read} may be referred to as a second read voltage.

[0067] In the read operation, read circuit 350 may read data from each of the second to n th memory blocks BLK_2 to BLK_n of memory cell array 310 and may transfer the read data to a data I/O circuit which outputs the read data to memory controller 210. Also, in the initialization information read operation, read circuit 350 may read the initialization information stored in the first memory block BLK_1 of memory cell array 310 and may set the read initialization information in set register 320 of control circuit 330. Read circuit 350 may include elements such as a page register or a page buffer, which performs reading of data, and a column selection circuit which selects the bit lines BLs .

[0068] In response to control by control circuit 330, voltage generator 360 may generate voltages (i.e., word line voltages) which are to be provided to the word lines WLs of memory cell array 310. In the program operation, voltage generator 360 may generate the program voltage V_{pgm} which is to be provided to a selected word line and the pass voltage V_{pass} which is to be provided to an unselected word line. In the read operation, voltage generator 360 may generate the read voltage V_{rd} which is to be provided to a selected word line and the high read pass voltage V_{read_H} which is to be provided to an unselected word line. Voltage generator 360 may pump the source voltage V_{DD} to generate a high voltage and may generate the program voltage V_{pgm} , the pass voltage V_{pass} , and the high read pass voltage V_{read_H} from the generated high voltage. In some embodiments, voltage generator 360 may be provided with the source voltage V_{DD} from memory controller 210. According to other embodiments, voltage generator 360 may be provided with the source voltage V_{DD} without passing through memory controller 210.

[0069] Voltage generator 360 may include a low voltage generation circuit 362 which generates the low read pass voltage V_{read_L} to be provided to an unselected word line in the initialization information read operation, in response to the voltage control signal $CTRL_Vol$ provided from control circuit 330. Low voltage generation circuit 362 may generate the low read pass voltage V_{read_L} to be provided to an unselected word line in the initialization information read operation, based on the source voltage V_{DD} . Low voltage generation circuit 362 may generate the low read pass voltage V_{read_L} as a voltage generated by dividing the source voltage V_{DD} (e.g., with a voltage divider such as a resistor divider or ladder). Embodiments of low voltage generation circuit 362 will be described below in detail with reference to FIGS. 7 to 12.

[0070] FIGS. 4 and 5 are diagrams for describing the first memory block BLK_1 of FIG. 3. FIG. 4 is a circuit diagram of a NAND string NS storing initialization information in the first memory block BLK_1 . FIG. 5 is a graph showing a

threshold voltage distribution of single level cells of the first memory block BLK_1 . In FIG. 5, the abscissa axis represents a threshold voltage V_{th} , and the ordinate axis represents the number of memory cells.

[0071] Referring to FIG. 4, a NAND string NS may include a string selection transistor SST , first to eighth memory cells MC_1 to MC_8 , and a ground selection transistor GST . For example, initialization information may be stored in the fourth and fifth memory cells MC_4 and MC_5 of the first to eighth memory cells MC_1 to MC_8 .

[0072] The first to eighth memory cells MC_1 to MC_8 may be in an erase state through a first-performed erase operation before the initialization information is stored in the fourth and fifth memory cells MC_4 and MC_5 , namely, before the fourth and fifth memory cells MC_4 and MC_5 are programmed. Subsequently, a program operation of storing the initialization information in the fourth and fifth memory cells MC_4 and MC_5 of the first to eighth memory cells MC_1 to MC_8 may be performed. Therefore, the fourth and fifth memory cells MC_4 and MC_5 may be in a program state, and the first to third memory cells MC_1 to MC_3 and the sixth to eighth memory cells MC_6 to MC_8 may be in the erase state.

[0073] In an initialization information read operation, in order to read the initialization information stored in the fourth and fifth memory cells MC_4 and MC_5 , a read voltage V_{rd} may be applied to selected fourth and fifth word lines WL_4 and WL_5 according to a predetermined order, and a read pass voltage V_{read} may be applied to unselected first to third word lines WL_1 to WL_3 and sixth to eighth word lines WL_6 to WL_8 . Also, a voltage (for example, the read pass voltage V_{read}) for turning on the string selection transistor SST and the ground selection transistor GST may be applied to a string selection line SSL and a ground selection line GSL .

[0074] For example, the read voltage V_{rd} may be a voltage for determining program states of the first to eighth memory cells MC_1 to MC_8 and may have a level between threshold voltage distributions based on the program states of the first to eighth memory cells MC_1 to MC_8 .

[0075] In a general read method, the read pass voltage V_{read} may be a voltage for turning on each of the first to eighth memory cells MC_1 to MC_8 regardless of the program states of the first to eighth memory cells MC_1 to MC_8 , and may be a high voltage.

[0076] The first to eighth memory cells MC_1 to MC_8 storing the initialization information may be single level cells, and thus, as shown in FIG. 5, may have one of an erase state E and a program state P . Therefore, a ground voltage (i.e., a voltage of 0 V) between a distribution based on the erase state E and a distribution based on the program state P may be set as the read voltage V_{rd} which is applied to the selected fourth and fifth word lines WL_4 and WL_5 . A high read pass voltage V_{read_H} may be applied to the unselected first to third word lines WL_1 to WL_3 and sixth to eighth word lines WL_6 to WL_8 , based on the general read method. The high read pass voltage V_{read_H} may be a voltage which is greater than a threshold voltage distribution based on the program state P .

[0077] In this case, voltage generator 360 (see FIG. 3) may perform a pumping operation using a source voltage V_{DD} to generate the high read pass voltage V_{read_H} . Therefore, non-volatile memory device 220 (see FIG. 3) may perform the pumping operation for generating the high read pass

voltage Vread_H in the initialization information read operation, and thus, a consumption current may increase.

[0078] FIG. 6 is a diagram for conceptually describing an embodiment of an initialization information reading method.

[0079] Referring to FIGS. 4 and 6, when the memory cells of the first memory block BLK1 (see FIG. 3) storing the initialization information are single level cells, a distribution of memory cells with respect to a threshold voltage Vth is shown. In the NAND string NS of FIG. 4, the fourth and fifth memory cells MC1 and MC5 may be in a program state P, and the first to third memory cells MC1 to MC3 and the sixth to eighth memory cells MC6 to MC8 may be in an erase state E. The memory cells MC1 to MC3 and MC6 to MC8 having the erase state E may have a negative (−) threshold voltage Vth, and thus, as shown, even when one of the first to fifth read pass voltages Vread_L0 to Vread_L4 is applied to unselected word lines WL1 to WL3 and WL6 to WL8, the memory cells MC1 to MC3 and MC6 to MC8 may be turned on.

[0080] For example, the first read pass voltage Vread_L0 may be set to 0 V, namely, a ground voltage VSS level, and the fifth read pass voltage Vread_L4 may be set to a source voltage VDD level. The number of read pass voltages Vread_L0 to Vread_L4 between the ground voltage VSS and the source voltage VDD illustrated in FIG. 6 is five, but embodiments are not limited thereto. A low read pass voltage Vread_L in an initialization information read operation according to an embodiment may be set as at least one voltage between the low read pass voltage Vread_L and the ground voltage VSS.

[0081] The first to fifth read pass voltages Vread_L0 to Vread_L4 may be provided from low voltage generation circuit 362 which divides the source voltage VDD. A detailed configuration of low voltage generation circuit 362 will be described below with reference to FIGS. 7 to 12.

[0082] FIGS. 7 to 9 are diagrams for exemplarily describing an embodiment of low voltage generation circuit 362 of FIG. 3.

[0083] Referring to FIG. 7, low voltage generation circuit 362 may include a voltage divider 710 and a selector 720. Voltage divider 710 may include a plurality of resistors R0 to R3 which are serially connected between a source voltage VDD and a ground voltage VSS. Voltages of both ends of each of the plurality of resistors R0 to R3 may be output as first to fifth read pass voltages Vread_L0 to Vread_L4.

[0084] When the plurality of resistors R0 to R3 have the same resistance values, the first to fifth read pass voltages Vread_L0 to Vread_L4 may have an equal voltage difference as shown in FIG. 6. For example, when the plurality of resistors R0 to R3 have different resistance values, the first to fifth read pass voltages Vread_L0 to Vread_L4 may have different voltage differences as shown in FIG. 8 or FIG. 9.

[0085] In FIG. 8, when resistance values R0 to R3 of the plurality of resistors R0 to R3 have a relationship of $R3 > R2 > R1 > R0$, the first to fifth read pass voltages Vread_L0 to Vread_L4 output from voltage divider 710 are shown.

[0086] In FIG. 9, when resistance values R0 to R3 of the plurality of resistors R0 to R3 have a relationship of $R3 < R2 < R1 < R0$, the first to fifth read pass voltages Vread_L0 to Vread_L4 output from voltage divider 710 are shown.

[0087] In response to the voltage control signal CTRL_Vol provided from control circuit 330, selector 720 may select one read pass voltage from among the first to fifth read pass

voltages Vread_L0 to Vread_L4 output from voltage divider 710 and may output the selected read pass voltage as a low read pass voltage Vread_L.

[0088] Therefore, in an initialization information read operation, in response to the voltage control signal CTRL_Vol, low voltage generation circuit 362 may generate, as the low read pass voltage Vread_L, one of the first to fifth read pass voltages Vread_L0 to Vread_L4 between the ground voltage VSS and the source voltage VDD.

[0089] FIGS. 10 to 12 are diagrams for exemplarily describing other embodiments of low voltage generation circuit 362 of FIG. 3.

[0090] Referring to FIG. 10, a low voltage generation circuit 362a may include first and second resistors Ra and Rb, which are serially connected between a source voltage VDD and a ground voltage VSS and may output a low read pass voltage Vread_L to a connection node between the first and second resistors Ra and Rb. A resistance of the second resistor Rb may vary according to the voltage control signal CTRL_Vol provided from control circuit 330.

[0091] In an initialization information read operation, low voltage generation circuit 362a may generate the low read pass voltage Vread_L as a voltage generated from the source voltage VDD divided by the first and second resistors Ra and Rb.

[0092] Referring to FIG. 11, a low voltage generation circuit 362b may include a first resistor R and a plurality of resistors RS0 to RS3, which are serially connected between a source voltage VDD and a ground voltage VSS, and a plurality of transistors MS0 to MS3 connected between the plurality of resistors RS0 to RS3. A voltage corresponding to a voltage control signal code CTRL_Vol[0:3] provided as bit information from control circuit 330 may be applied to a gate of each of the transistors MS0 to MS3.

[0093] Low voltage generation circuit 362b may output a low read pass voltage Vread_L to a connection node between the first resistor R and the plurality of resistors RS0 to RS3. The first resistor R and the plurality of resistors RS0 to RS3 may have the same resistance values. According to an embodiment, the first resistor R and the plurality of resistors RS0 to RS3 may have different resistance values.

[0094] In an initialization information read operation, low voltage generation circuit 362b may generate the low read pass voltage Vread_L as a voltage generated from the source voltage VDD divided by the resistors RS0 to RS3 short-circuited based on the voltage control signal code CTRL_Vol[0:3].

[0095] Referring to FIG. 12, a low voltage generation circuit 362c may include a first resistor R, a plurality of resistors RP0 to RP3 connected in parallel between the first resistor R and a ground voltage VSS, and a plurality of transistors MP0 to MP3 connected between the plurality of resistors RP0 to RP3. A voltage corresponding to a voltage control signal code CTRL_Vol[0:3] provided from control circuit 330 may be applied to a gate of each of the transistors MP0 to MP3.

[0096] Low voltage generation circuit 362c may output a low read pass voltage Vread_L to a connection node between the first resistor R and the plurality of resistors RP0 to RP3. The first resistor R and the plurality of resistors RP0 to RP3 may have the same resistance values. According to an embodiment, the first resistor R and the plurality of resistors RP0 to RP3 may have different resistance values.

[0097] In an initialization information read operation, low voltage generation circuit 362c may generate the low read pass voltage Vread_L as a voltage generated from the source voltage VDD divided by the resistors RP0 to RP3 short-circuited based on the voltage control signal code CTRL_Vol[0:3].

[0098] FIG. 13 is a flowchart illustrating an embodiment of an initialization information reading method of memory device 220 illustrated in FIG. 3.

[0099] Referring to FIG. 13, in operation S1310, a non-volatile memory device (220 of FIG. 3) may detect power-up. Non-volatile memory device 220 may generate a voltage control signal CTRL_Vol, based on the power-up.

[0100] In operation S1320, in response to the voltage control signal CTRL_Vol, the non-volatile memory device 220 may divide a source voltage VDD to generate a low read pass voltage Vread_L which is to be provided to unselected word lines in an initialization information read operation. The low read pass voltage Vread_L may be set as at least one voltage between a ground voltage VSS and the source voltage VDD. In response to the voltage control signal CTRL_Vol, non-volatile memory device 220 may allow the source voltage VDD not to be pumped during the initialization information read operation.

[0101] In operation S1330, non-volatile memory device 220 may provide the low read pass voltage Vread_L to the unselected word lines and may provide a read voltage Vrd to a selected word line to read initialization information stored in memory cells of a first memory block BLK1. Non-volatile memory device 220 may set the read initialization information in a set register.

[0102] FIG. 14 is a table showing an example where word line voltages are applied based on the initialization information read operation of FIG. 13. The table of FIG. 14 shows a result obtained by comparing an example initialization information read operation of a non-volatile memory device performed as described above with respect to FIG. 5 and an example initialization information read operation of a non-volatile memory device as described above with respect to FIG. 6.

[0103] Referring to the table of FIG. 14 along with FIG. 4, in a conventional initialization information reading method, the high read pass voltage Vread_H may be applied to the unselected first to third word lines WL1 to WL3 and sixth to eighth word lines WL6 to WL8. The high read pass voltage Vread_H may be a voltage generated by pumping the source voltage VDD. The read voltage Vrd may be applied to the selected fourth and fifth word lines WL4 and WL5 according to a predetermined order. The read voltage Vrd may be a voltage for determining program states of the first to eighth memory cells MC1 to MC8. The first to eighth memory cells MC1 to MC8 storing the initialization information may be single level cells, and thus, as shown in FIG. 5, may have one of the erase state E and the program state P. Therefore, a voltage of 0 V between a distribution based on the erase state E and a distribution based on the program state P may be set as the read voltage Vrd which is applied to the selected fourth and fifth word lines WL4 and WL5.

[0104] In contrast to the above example, in an initialization information reading method as disclosed herein, the low read pass voltage Vread_L may be applied to the unselected first to third word lines WL1 to WL3 and sixth to eighth word lines WL6 to WL8. The low read pass voltage Vread_L may be a voltage generated by dividing the source voltage

VDD, and as shown in FIGS. 6, 9, and 10, may be set as one of the first to fifth read pass voltages Vread_L0 to Vread_L4.

[0105] FIG. 15 is a diagram illustrating a consumption current pattern when an initialization information read operation is performed by using an embodiment of the non-volatile memory device illustrated in FIG. 3.

[0106] Referring to FIG. 15, in the initialization information read operation of non-volatile memory device 220 (see FIG. 3), a consumption current pattern 1510 when the low read pass voltage Vread_L applied to unselected word lines is applied as a voltage generated by dividing the source voltage VDD is shown. Also, a consumption current pattern 1520 when the high read pass voltage Vread_H generated by pumping the source voltage VDD is applied to the unselected word lines is shown. A consumption current peak 1522 caused by a pumping operation of generating the high read pass voltage Vread_H may be observed in consumption current pattern 1520.

[0107] In comparison with consumption current pattern 1520 when the high read pass voltage Vread_H is applied as a high pumping voltage, it may be seen that in consumption current pattern 1510 when the low read pass voltage Vread_L generated by dividing the source voltage VDD is applied to unselected word lines, a consumption current is considerably reduced. Also, since a high voltage pumping operation is not performed, a consumption current peak is not shown in consumption current pattern 1510.

[0108] Therefore, when an SSD uses non-volatile memory device 220 which applies the low read pass voltage Vread_L, generated by dividing the source voltage VDD, to unselected word lines in the initialization information read operation, a consumption current may be easily reduced. Also, in a mass SSD, a consumption current peak may not occur in the initialization information read operation despite an increase in number of non-volatile memory devices 220, and thus, the mass SSD may stably perform an initialization operation.

[0109] FIG. 16 is a block diagram illustrating a server system 1600 to which a storage device including embodiments of a non-volatile memory device are applied.

[0110] Referring to FIG. 16, server system 1600 may include a plurality of servers 110_1 to 110_N. The plurality of servers 110_1 to 110_N may be connected to a manager 1610. Each of the plurality of servers 110_1 to 110_N may be the same as or similar to server 110 described above with reference to FIG. 1.

[0111] The plurality of servers 110_1 to 110_N may each include a plurality of mass SSDs, and the mass SSDs may include a plurality of non-volatile memory devices. The non-volatile memory devices may store initialization information in memory cells of a first memory block including single level cells among a plurality of memory blocks and may store user data in the other memory blocks. When power-up is detected in booting, the non-volatile memory devices may divide a source voltage to generate a low read pass voltage which is to be provided to unselected word lines in an initialization information read operation. The low read pass voltage may be set as at least one voltage between a ground voltage and the source voltage. The non-volatile memory devices may allow the source voltage not to be pumped in the initialization information read operation, based on the power-up. In the initialization information read operation, the non-volatile memory devices may select the first memory block, provide the low read pass voltage to

unselected word lines, and provide a read voltage to a selected word line, thereby reading the initialization information stored in the memory cells of the first memory block. The non-volatile memory devices may set the read initialization information in a set register.

[0112] FIG. 17 is a block diagram illustrating a storage cluster 1700 to which a storage device including embodiments of a non-volatile memory device is applied.

[0113] Referring to FIG. 17, in the big data and artificial intelligence (AI) age, storage cluster 1700 is attracting attention as a high performance computing infrastructure which quickly calculates massive data. Storage cluster 1700 may configure a parallel computing environment through mass clustering, thereby maximizing calculation performance. Storage cluster 1700 may provide a network-connected storage or a storage area network, based on the number of storage memories and the flexibility and reconfigurable disposition of a physical component.

[0114] Storage cluster 1700 may include a data center 1705 implemented with a plurality of server systems 1600_1 to 1600_N. Each of the plurality of server systems 1600_1 to 1600_N may be the same as or similar to server system 1600 illustrated in FIG. 16.

[0115] The plurality of server systems 1600_1 to 1600_N may communicate with various storage nodes 1720_1 to 1720_M over a network 1710 such as a computer network (for example, LAN or WAN) or the Internet. According to some embodiments, storage nodes 1720_1 to 1720_M may not be sequentially arranged or may not be adjacent to one another. For example, storage nodes 1720_1 to 1720_M may be ones of client computers, servers, remote data centers, and storage systems.

[0116] One server system receiving a request of each of storage nodes 1720_1 to 1720_M among the plurality of server systems 1600_1 to 1600_N may include a plurality of mass SSDs, and the mass SSDs may include a plurality of non-volatile memory devices. The non-volatile memory devices may store initialization information in memory cells of a first memory block including single level cells among a plurality of memory blocks and may store user data in the other memory blocks. When power-up is detected in booting, the non-volatile memory devices may divide a source voltage to generate a low read pass voltage which is to be provided to unselected word lines in an initialization information read operation. The low read pass voltage may be set as at least one voltage between a ground voltage and the source voltage. The non-volatile memory devices may allow the source voltage not to be pumped in the initialization information read operation, based on the power-up. In the initialization information read operation, the non-volatile memory devices may select the first memory block, provide the low read pass voltage to unselected word lines, and provide a read voltage to a selected word line, thereby reading the initialization information stored in the memory cells of the first memory block. The non-volatile memory devices may set the read initialization information in a set register.

[0117] FIG. 18 is a block diagram illustrating a system 1800 including a non-volatile memory device according to embodiments.

[0118] Referring to FIG. 18, system 1800 may include a processing unit 1810, a volatile memory unit 1820, a resistive memory unit 1830, and a mass storage unit 1840. Also, system 1800 may be a mobile device, a PC, a server

computer, a programmable home appliance, or a general-use or special-purpose computer system such as a main frame computer.

[0119] A functional unit described in the present embodiment may be classified as a module, for implementation independence. For example, the module may be implemented as a computing very large scale integration (VLSI) circuit or a hardware circuit including a semiconductor such as a gate array, a logic chip, a transistor, or a discrete component. The module may be implemented as a programmable hardware device, for example, a programmable gate array, a programmable gate logic, or a programmable gate device. Also, the module may be implemented as software including executable code, an object, a procedure, or a function.

[0120] Processing unit 1810 may execute an OS and a plurality of software systems and may perform calculations or tasks. Processing unit 1810 may be a microprocessor or a CPU.

[0121] Volatile memory unit 1820, a cache memory or a working memory of system 1800, may denote a medium which stores data temporarily or in the short term. Volatile memory unit 1820 may include one or more memory devices, and for example, may include DRAM.

[0122] Resistive memory unit 1830 may be used to act as a cache of mass storage unit 1840. Resistive memory unit 1830 may store a frequently accessed application or some data of an OS. Resistive memory unit 1830 may include one or more memory devices, and for example, may include DRAM.

[0123] Mass storage unit 1840 may be implemented as an SSD, a PCIe memory module, or NVMe. Optionally, one or more tiers of mass storage unit 1840 may be implemented with one or more network-accessible devices and/or services, for example, clients, servers, server palm(s), server cluster(s), application server(s), or message server(s), accessed based on NVMe-oF and/or RDMA. Mass storage unit 1840 may denote a storage medium which stores user data in the long term in system 1800. Mass storage unit 1840 may store an application program, program data, and/or the like.

[0124] Mass storage unit 1840 may include a plurality of mass SSDs, and the mass SSDs may include a plurality of non-volatile memory devices. The non-volatile memory devices may store initialization information in memory cells of a first memory block including single level cells among a plurality of memory blocks and may store user data in the other memory blocks. When power-up is detected in booting, the non-volatile memory devices may divide a source voltage to generate a low read pass voltage which is to be provided to unselected word lines in an initialization information read operation. The low read pass voltage may be set as at least one voltage between a ground voltage and the source voltage. The non-volatile memory devices may allow the source voltage not to be pumped in the initialization information read operation, based on the power-up. In the initialization information read operation, the non-volatile memory devices may select the first memory block, provide the low read pass voltage to unselected word lines, and provide a read voltage to a selected word line, thereby reading the initialization information stored in the memory cells of the first memory block. The non-volatile memory devices may set the read initialization information in a set register.

[0125] FIG. 19 is a block diagram illustrating an example where embodiments of a non-volatile memory device 1900 are applied to a memory card system.

[0126] Referring to FIG. 19, memory card system 1900 may include a host 1910 and a memory card 1920. Host 1910 may include a host controller 1911 and a host connector 1912. Memory card 1920 may include a card connector 1921, a card controller 1922, and a memory device 1923.

[0127] Host 1910 may write data in memory card 1920, or may read the data stored in memory card 1920. Host controller 1911 may transmit a command CMD, a clock signal CLK, and data DATA to memory card 1920 through host connector 1912.

[0128] In response to the command CMD received through card connector 1921, card controller 1922 may store data in memory device 1923 in synchronization with a clock signal generated by a clock generator included in card controller 1922. Memory device 1923 may store data transmitted from host 1910. Memory device 1923 may include a plurality of mass SSDs, and the mass SSDs may include a plurality of non-volatile memory devices. The non-volatile memory devices may store initialization information in memory cells of a first memory block including single level cells among a plurality of memory blocks and may store user data in the other memory blocks. When power-up is detected in booting, the non-volatile memory devices may divide a source voltage to generate a low read pass voltage which is to be provided to unselected word lines in an initialization information read operation. The low read pass voltage may be set as at least one voltage between a ground voltage and the source voltage. The non-volatile memory devices may allow the source voltage not to be pumped in the initialization information read operation, based on the power-up. In the initialization information read operation, the non-volatile memory devices may select the first memory block, provide the low read pass voltage to unselected word lines, and provide a read voltage to a selected word line, thereby reading the initialization information stored in the memory cells of the first memory block. The non-volatile memory devices may set the read initialization information in a set register.

[0129] Memory card 1920 may be implemented with a compact flash card (CFC), a Microdrive, a smart media card (SMC), a multimedia card (MMC), a security digital card (SDC), a memory stick, a universal serial bus (USB) flash memory driver, and/or the like.

[0130] FIG. 20 illustrates a portion of a cross-section of the non-volatile memory device of FIG. 3.

[0131] Referring to FIGS. 3 and 20, a memory device 220 may have a chip-to-chip (C2C) structure. The C2C structure may refer to a structure formed by manufacturing an upper chip including a cell region CELL on a first wafer, manufacturing a lower chip including a peripheral circuit region PERI on a second wafer, different from the first wafer, and then connecting the upper chip and the lower chip in a bonding manner. For example, the bonding manner may include a method of electrically connecting a bonding metal formed on an uppermost metal layer of the upper chip and a bonding metal formed on an uppermost metal layer of the lower chip. For example, when the bonding metals may be formed of copper (Cu), the bonding manner may be a Cu—Cu bonding, and the bonding metals may also be formed of aluminum or tungsten.

[0132] Each of the peripheral circuit region PERI and the cell region CELL of the memory device 40 may include an external pad bonding area PA, a word line bonding area WLBA, and a bit line bonding area BLBA.

[0133] The peripheral circuit region PERI may include a first substrate 1210, an interlayer insulating layer 1215, a plurality of circuit elements 1220a, 1220b, and 1220c formed on the first substrate 1210, first metal layers 1230a, 1230b, and 1230c respectively connected to the plurality of circuit elements 1220a, 1220b, and 1220c, and second metal layers 1240a, 1240b, and 1240c formed on the first metal layers 1230a, 1230b, and 1230c. In an example embodiment, the first metal layers 1230a, 1230b, and 1230c may be formed of tungsten having relatively high resistance, and the second metal layers 1240a, 1240b, and 1240c may be formed of copper having relatively low resistance.

[0134] In an example embodiment illustrate in FIG. 20, although the first metal layers 1230a, 1230b, and 1230c and the second metal layers 1240a, 1240b, and 1240c are shown and described, they are not limited thereto, and one or more metal layers may be further formed on the second metal layers 1240a, 1240b, and 1240c. At least a portion of the one or more metal layers formed on the second metal layers 1240a, 1240b, and 1240c may be formed of aluminum or the like having a lower resistance than those of copper forming the second metal layers 1240a, 1240b, and 1240c.

[0135] The interlayer insulating layer 1215 may be disposed on the first substrate 1210 and cover the plurality of circuit elements 1220a, 1220b, and 1220c, the first metal layers 1230a, 1230b, and 1230c, and the second metal layers 1240a, 1240b, and 1240c. The interlayer insulating layer 1215 may include an insulating material such as silicon oxide, silicon nitride, or the like.

[0136] Lower bonding metals 1271b and 1272b may be formed on the second metal layer 1240b in the word line bonding area WLBA. In the word line bonding area WLBA, the lower bonding metals 1271b and 1272b in the peripheral circuit region PERI may be electrically connected to upper bonding metals 1371b and 1372b in the cell region CELL in a bonding manner, and the lower bonding metals 1271b and 1272b and the upper bonding metals 1371b and 1372b may be formed of aluminum, copper, tungsten, or the like. Further, the upper bonding metals 1371b and 1372b in the cell region CELL may be referred as first metal pads and the lower bonding metals 1271b and 1272b in the peripheral circuit region PERI may be referred as second metal pads.

[0137] The cell region CELL may include at least one memory block. The cell region CELL may include a second substrate 1310 and a common source line 1320. On the second substrate 1310, a plurality of word lines 1331 to 1338 (i.e., 1330) may be stacked in a direction (a Z-axis direction), perpendicular to an upper surface of the second substrate 1310. At least one string select line and at least one ground select line may be arranged on and below the plurality of word lines 1330, respectively, and the plurality of word lines 1330 may be disposed between the at least one string select line and the at least one ground select line.

[0138] In the bit line bonding area BLBA, a channel structure CH may extend in a direction, perpendicular to the upper surface of the second substrate 1310, and pass through the plurality of word lines 1330, the at least one string select line, and the at least one ground select line. The channel structure CH may include a data storage layer, a channel layer, a buried insulating layer, and the like, and the channel

layer may be electrically connected to a first metal layer **1350c** and a second metal layer **1360c**. For example, the first metal layer **1350c** may be a bit line contact, and the second metal layer **1360c** may be a bit line. In an example embodiment, the bit line **1360c** may extend in a first direction (a Y-axis direction), parallel to the upper surface of the second substrate **1310**.

[0139] In an example embodiment illustrated in FIG. 20, an area in which the channel structure CH, the bit line **1360c**, and the like are disposed may be defined as the bit line bonding area BLBA. In the bit line bonding area BLBA, the bit line **1360c** may be electrically connected to the circuit elements **1220c** providing a page buffer **1393** in the peripheral circuit region PERI. For example, the bit line **1360c** may be connected to upper bonding metals **1371c** and **1372c** in the cell region CELL, and the upper bonding metals **1371c** and **1372c** may be connected to lower bonding metals **1271c** and **1272c** connected to the circuit elements **1220c** of the page buffer **1393**.

[0140] In the word line bonding area WLBA, the plurality of word lines **1330** may extend in a second direction (an X-axis direction), parallel to the upper surface of the second substrate **1310**, and may be connected to a plurality of cell contact plugs **1341** to **1347** (i.e., **1340**). The plurality of word lines **1330** and the plurality of cell contact plugs **1340** may be connected to each other in pads provided by at least a portion of the plurality of word lines **1330** extending in different lengths in the second direction. A first metal layer **1350b** and a second metal layer **1360b** may be connected to an upper portion of the plurality of cell contact plugs **1340** connected to the plurality of word lines **1330**, sequentially. The plurality of cell contact plugs **1340** may be connected to the circuit region PERI by the upper bonding metals **1371b** and **1372b** of the cell region CELL and the lower bonding metals **1271b** and **1272b** of the peripheral circuit region PERI in the word line bonding area WLBA.

[0141] The plurality of cell contact plugs **1340** may be electrically connected to the circuit elements **1220b** providing a row decoder **1394** in the peripheral circuit region PERI. In an example embodiment, operating voltages of the circuit elements **1220b** providing the row decoder **1394** may be different than operating voltages of the circuit elements **1220c** providing the page buffer **1393**. For example, operating voltages of the circuit elements **1220c** providing the page buffer **1393** may be greater than operating voltages of the circuit elements **1220b** providing the row decoder **1394**.

[0142] A common source line contact plug **1380** may be disposed in the external pad bonding area PA. The common source line contact plug **1380** may be formed of a conductive material such as a metal, a metal compound, polysilicon, or the like, and may be electrically connected to the common source line **1320**. A first metal layer **1350a** and a second metal layer **1360a** may be stacked on an upper portion of the common source line contact plug **1380**, sequentially. For example, an area in which the common source line contact plug **1380**, the first metal layer **1350a**, and the second metal layer **1360a** are disposed may be defined as the external pad bonding area PA.

[0143] Input-output pads **1205** and **1305** may be disposed in the external pad bonding area PA. Referring to FIG. 20, a lower insulating film **1201** covering a lower surface of the first substrate **1210** may be formed below the first substrate **1210**, and a first input-output pad **1205** may be formed on the lower insulating film **1201**. The first input-output pad

1205 may be connected to at least one of the plurality of circuit elements **1220a**, **1220b**, and **1220c** disposed in the peripheral circuit region PERI through a first input-output contact plug **1203**, and may be separated from the first substrate **1210** by the lower insulating film **1201**. In addition, a side insulating film may be disposed between the first input-output contact plug **1203** and the first substrate **1210** to electrically separate the first input-output contact plug **1203** and the first substrate **1210**.

[0144] Referring to FIG. 20, an upper insulating film **1301** covering the upper surface of the second substrate **1310** may be formed on the second substrate **1310**, and a second input-output pad **1305** may be disposed on the upper insulating layer **1301**. The second input-output pad **1305** may be connected to at least one of the plurality of circuit elements **1220a**, **1220b**, and **1220c** disposed in the peripheral circuit region PERI through a second input-output contact plug **1303**.

[0145] According to embodiments, the second substrate **1310** and the common source line **1320** may not be disposed in an area in which the second input-output contact plug **1303** is disposed. Also, the second input-output pad **1305** may not overlap the word lines **1330** in the third direction (the Z-axis direction). Referring to FIG. 20, the second input-output contact plug **1303** may be separated from the second substrate **1310** in a direction, parallel to the upper surface of the second substrate **1310**, and may pass through the interlayer insulating layer **1315** of the cell region CELL to be connected to the second input-output pad **1305**.

[0146] According to embodiments, the first input-output pad **1205** and the second input-output pad **1305** may be selectively formed. For example, the memory device **220** may include only the first input-output pad **1205** disposed on the first substrate **1210** or the second input-output pad **1305** disposed on the second substrate **1310**. Alternatively, the memory device **220** may include both the first input-output pad **1205** and the second input-output pad **1305**.

[0147] A metal pattern in an uppermost metal layer may be provided as a dummy pattern or the uppermost metal layer may be absent, in each of the external pad bonding area PA and the bit line bonding area BLBA, respectively included in the cell region CELL and the peripheral circuit region PERI.

[0148] In the external pad bonding area PA, the memory device **220** may include a lower metal pattern **1273a**, corresponding to an upper metal pattern **1372a** formed in an uppermost metal layer of the cell region CELL, and having the same shape as the upper metal pattern **1372a** of the cell region CELL, in an uppermost metal layer of the peripheral circuit region PERI. In the peripheral circuit region PERI, the lower metal pattern **1273a** formed in the uppermost metal layer of the peripheral circuit region PERI may not be connected to a contact. Similarly, in the external pad bonding area PA, an upper metal pattern, corresponding to the lower metal pattern formed in an uppermost metal layer of the peripheral circuit region PERI, and having the same shape as a lower metal pattern of the peripheral circuit region PERI, may be formed in an uppermost metal layer of the cell region CELL.

[0149] The lower bonding metals **1271b** and **1272b** may be formed on the second metal layer **1240b** in the word line bonding area WLBA. In the word line bonding area WLBA, the lower bonding metals **1271b** and **1272b** of the peripheral circuit region PERI may be electrically connected to the

upper bonding metals **1371b** and **1372b** of the cell region CELL by a Cu—Cu bonding.

[0150] Further, the bit line bonding area BLBA, an upper metal pattern **1392**, corresponding to a lower metal pattern **1252** formed in the uppermost metal layer of the peripheral circuit region PERI, and having the same shape as the lower metal pattern **1252** of the peripheral circuit region PERI, may be formed in an uppermost metal layer of the cell region CELL. A contact may not be formed on the upper metal pattern **1392** formed in the uppermost metal layer of the cell region CELL.

[0151] In an example embodiment, corresponding to a metal pattern formed in an uppermost metal layer in one of the cell region CELL and the peripheral circuit region PERI, a reinforcement metal pattern having the same shape as the metal pattern may be formed in an uppermost metal layer in another one of the cell region CELL and the peripheral circuit region PERI, and a contact may not be formed on the reinforcement metal pattern.

[0152] Referring to FIGS. 3 and 20, the peripheral circuit region PERI may include a plurality of circuit elements of the control circuit **330**, the read circuit **350**, and the voltage generator **360**.

[0153] The voltage generator **360** in the peripheral circuit region PERI may generate word line voltages including the program voltage V_{pgm} , the pass voltage V_{pass} , the read voltage V_{rd} , the high read pass voltage V_{read_H} , and the low read pass voltage V_{read_L} . The word line voltages generated in the peripheral circuit region PERI may be provided to the word line bonding area WLBA of the cell region CELL through the row decoder **1394**, the lower bonding metals **1271b** and **1272b** in the peripheral circuit region PERI, and the upper bonding metals **1371b** and **1372b** in the cell region CELL.

[0154] In the program operation, the program voltage V_{pgm} may be applied to a selected word line among the word lines **1330** of the word line bonding area WLBA, and a pass voltage V_{pass} may be applied to unselected word lines among the word lines **1330**. In the read operation, a read voltage V_{rd} may be provided to a selected word line among the word lines **1330**, and a high read pass voltage V_{read_H} having a high voltage level which is greater than the source voltage VDD level may be provided to unselected word lines among the word lines **1330**. In the initialization information read operation, the read voltage V_{rd} may be provided to a selected word line among the word lines **1330**, and a low read pass voltage V_{read_L} generated by dividing the source voltage VDD may be provided to unselected word lines among the word lines **1330**.

[0155] In the initialization information read operation, the initialization information stored in the memory cell connected to the selected word line may be output to the bit line **1360c** of the bit line bonding area BLBA.

[0156] The initialization information of the bit line **1360c** may be set in the set register **320** of the control circuit **330** through the page buffer **1393** in the peripheral circuit region PERI. Also, piece of the initialization information of the bit line **1360c** may be sent to a data I/O circuit including a circuit element **1220a** and output to memory controller **210** through the input-output pad **1305** in the external pad bonding area PA.

[0157] While the inventive concept has been particularly shown and described with reference to embodiments thereof, it will be understood that various changes in form

and details may be made therein without departing from the spirit and scope of the following claims.

What is claimed is:

1. A non-volatile memory device comprising:
 - a memory cell region including a first metal pad;
 - a peripheral circuit region including a second metal pad and being vertically connected to the memory cell region by the first metal pad and the second metal pad;
 - a memory cell array provided in the memory cell region, having memory cells connected to a plurality of word lines and being configured to store initialization information for the non-volatile memory device in the memory cells;
 - a voltage generator provided in the peripheral circuit region and being configured to receive a source voltage, generate a first read voltage from the source voltage, and generate a second read voltage from the source voltage, wherein the magnitude of the second read voltage exceeds the magnitude of the first read voltage and is less than or equal to the magnitude of the source voltage; and
 - a control circuit provided in the peripheral circuit region and being configured to control application of the first read voltage to a selected word line among the plurality of word lines, and control application of the second read voltage to unselected word lines among the plurality of word lines, in an initialization information read operation of reading the initialization information, wherein:
 - the voltage generator is configured to generate the second read voltage based on a voltage control signal provided by the control circuit in the initialization information read operation,
 - the voltage generator is configured to generate a third read voltage from the source voltage in a read operation of reading non-initialization information from first memory cells of the memory cell array, wherein the third read voltage is greater than the source voltage, and the control circuit is configured to apply the third read voltage to other unselected word lines, among the plurality of word lines, to read the non-initialization information from the first memory cells of the memory cell array.
2. The non-volatile memory device of claim 1, wherein each of the memory cells is a single level cell storing one-bit data.
3. The non-volatile memory device of claim 2, wherein the first read voltage is set to have a voltage level for discriminating between an erase state and a program state of a single level cell.
4. The non-volatile memory device of claim 3, wherein the first read voltage is set as a ground voltage.
5. The non-volatile memory device of claim 1, wherein the control circuit is configured to detect power-up of the non-volatile memory device and generate the voltage control signal.
6. The non-volatile memory device of claim 1, wherein the voltage generator comprises:
 - a voltage divider including a plurality of resistors serially connected between the source and a ground voltage, the voltage divider being configured to generate division voltages at both ends of each of the plurality of resistors; and

a selector configured to output one of the division voltages as the second read voltage based on the voltage control signal.

7. The non-volatile memory device of claim 1, further comprising a set register provided in the peripheral circuit region and configured to store the initialization information read through the initialization information read operation.

8. The non-volatile memory device of claim 1, wherein the initialization information comprises:

protection information about inhibition or permission of program or erase operations performed on the memory cell array;

trimming data for trimming an operating voltage level in a program, read, or erase operation mode of the non-volatile memory device;

column repair information for repairing a failed bit line of the non-volatile memory device; or

bad block information identifying bad memory cells of the non-volatile memory device.

9. The non-volatile memory device of claim 1, wherein the memory cell region is formed on a first wafer and the peripheral circuit region is formed on a second wafer.

10. A non-volatile memory device in a solid state drive (SSD), comprising:

a memory cell region including a first metal pad;

a peripheral circuit region including a second metal pad and being vertically connected to the memory cell region by the first metal pad and the second metal pad;

a memory cell array provided in the memory cell region and configured to store initialization information for the non-volatile memory device in memory cells of the memory cell array, the memory cells being connected to a plurality of word lines;

a voltage generator provided in the peripheral circuit region and configured to receive a source voltage, generate a first read voltage from the source voltage, and generate a second read voltage from the source voltage, wherein the second read voltage is greater than the first read voltage and is less than or equal to the source voltage; and

a control circuit provided in the peripheral circuit region and configured to detect power-up of the non-volatile memory device, generate a voltage control signal based on detecting a power-up state of the non-volatile memory, perform an initialization information read operation of reading the initialization information, the initialization information read operation applying the first read voltage to a selected word line among the plurality of word lines and applying the second read voltage to unselected word lines among the plurality of word lines, perform a read operation of reading non-initialization information, and output initialization information through an input/output pad in the peripheral circuit region to a memory controller in the SSD, wherein:

the voltage generator is configured to generate the second read voltage based on the voltage control signal provided by the control circuit in the initialization information read operation,

the voltage generator is configured to generate a third read voltage from the source voltage in the read operation, wherein the third read voltage is greater than the source voltage, and

the control circuit is configured to apply the first read voltage to another selected word line, among the plurality of word lines, and apply the third read voltage to other unselected word lines, among the plurality of word lines, to read the non-initialization information from other memory cells of the memory cell array.

11. The non-volatile memory device of claim 10, wherein each of the memory cells is a single level cell storing one-bit data.

12. The non-volatile memory device of claim 11, wherein the first read voltage is set to have a voltage level for differentiating an erase state and a program state of each of the single level cells.

13. The non-volatile memory device of claim 10, wherein the second read voltage level is between a ground voltage level and a level of the source voltage.

14. The non-volatile memory device of claim 10, further comprising a set register provided in the peripheral circuit region and configured to store the initialization information read through the initialization information read operation.

15. The non-volatile memory device of claim 10, wherein the initialization information comprises:

protection information about inhibition or permission of program or erase operations performed on the memory cell array;

trimming data for trimming an operating voltage level in a program, read, or erase operation mode of the non-volatile memory device;

column repair information for repairing a failed bit line of the non-volatile memory device; or

bad block information identifying bad memory cells of the non-volatile memory device.

16. A method comprising:

controlling, by a memory controller, an initialization information read operation and a read operation of a non-volatile memory device, the initialization information read operation reading initialization information for the non-volatile memory device, which is stored in first memory cells of a memory cell array of the non-volatile memory device, and the read operation reading non-initialization information for the non-volatile memory device, which is stored in a second memory cells of the memory cell array;

detecting, by the non-volatile memory device, a power-up state of the non-volatile memory device;

based on detecting of the power-up state, performing, by the non-volatile memory device, the initialization information read operation; and

outputting, by the non-volatile memory device, the initialization information read in the initialization information read operation to the memory controller, wherein:

the initialization information read operation comprises: applying to selected word lines connected to the first memory cells a first read voltage having a first read voltage level for discriminating between erase states and program states of the first memory cells; and

while applying the first read voltage to the selected word lines, applying to unselected word lines which are not connected to the first memory cells a second read voltage having a second read voltage level which is less than voltage levels of the program states of the first memory cells, the magnitude of the second read voltage exceeds the magnitude of the

first read voltage and is less than or equal to the magnitude of a source voltage used to generate each of the first read voltage and the second read voltage, and

the read operation comprises:

applying the first read voltage to another selected word line, among the word lines; and

applying a third read voltage whose magnitude exceeds that of the source voltage to other unselected word lines, among the word lines, to thereby read the non-initialization information from other memory cells of the non-volatile memory device.

17. The method of claim **16**, further comprising storing the initialization information read through the initialization information read operation in a set register of the non-volatile memory device.

18. The method of claim **16**, further comprising:

receiving the source voltage which is less than the voltage levels of the program states of the first memory cells; and

applying the source voltage to a low voltage generation circuit to generate the second read voltage which is less than voltage levels of the program states of the first memory cells.

19. The method of claim **18**, wherein the second read voltage level is between a ground voltage level and a level of the source voltage.

20. The method of claim **16**, wherein the initialization information comprises:

protection information about inhibition or permission of program or erase operations on the non-volatile memory device;

trimming data for trimming an operating voltage level in a program, read, or erase operation mode for the non-volatile memory device;

column repair information for repairing a failed bit line of the non-volatile memory device; or

bad block information identifying bad memory cells of the non-volatile memory device.

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